

Class 11

Van der Waals Materials

28.04.2025

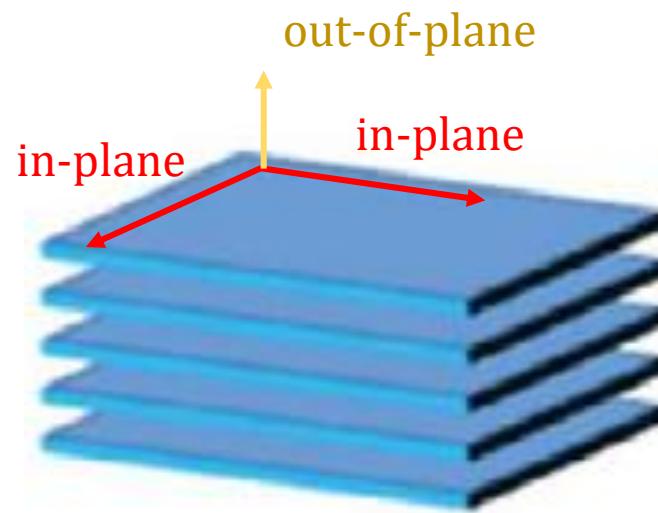
- ❑ Layered crystals
 - Crystal structure
 - Layer dependent band structure
 - Spin-valley locking
- ❑ Effect of stacking order
 - Parallel configuration
 - Antiparallel configuration
 - Twisted layers
- ❑ Doping strategies

VdW Materials = 2D Crystals

DEFINITION:

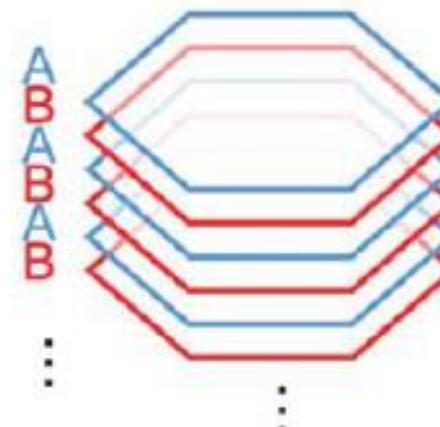
[...] layered materials with strong in-plane bonds and weak, van der Waals-like coupling between layers.

Novoselov et al. PNAS, 102, 30 (2005)

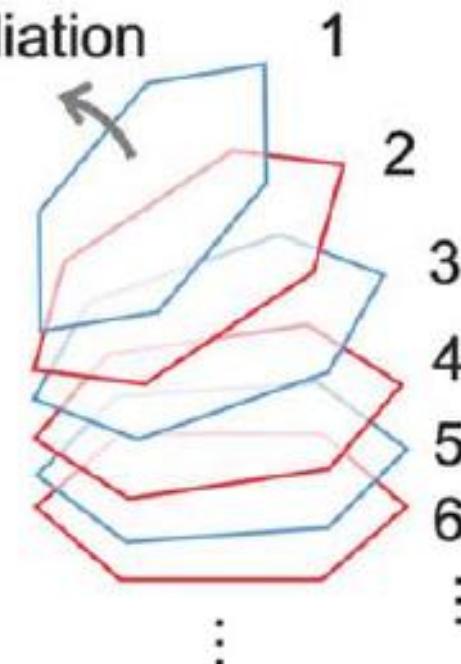


Yao, J.D. et al., Prog. Mat. Sc., 106 (2019)

Bulk Crystal



Exfoliation



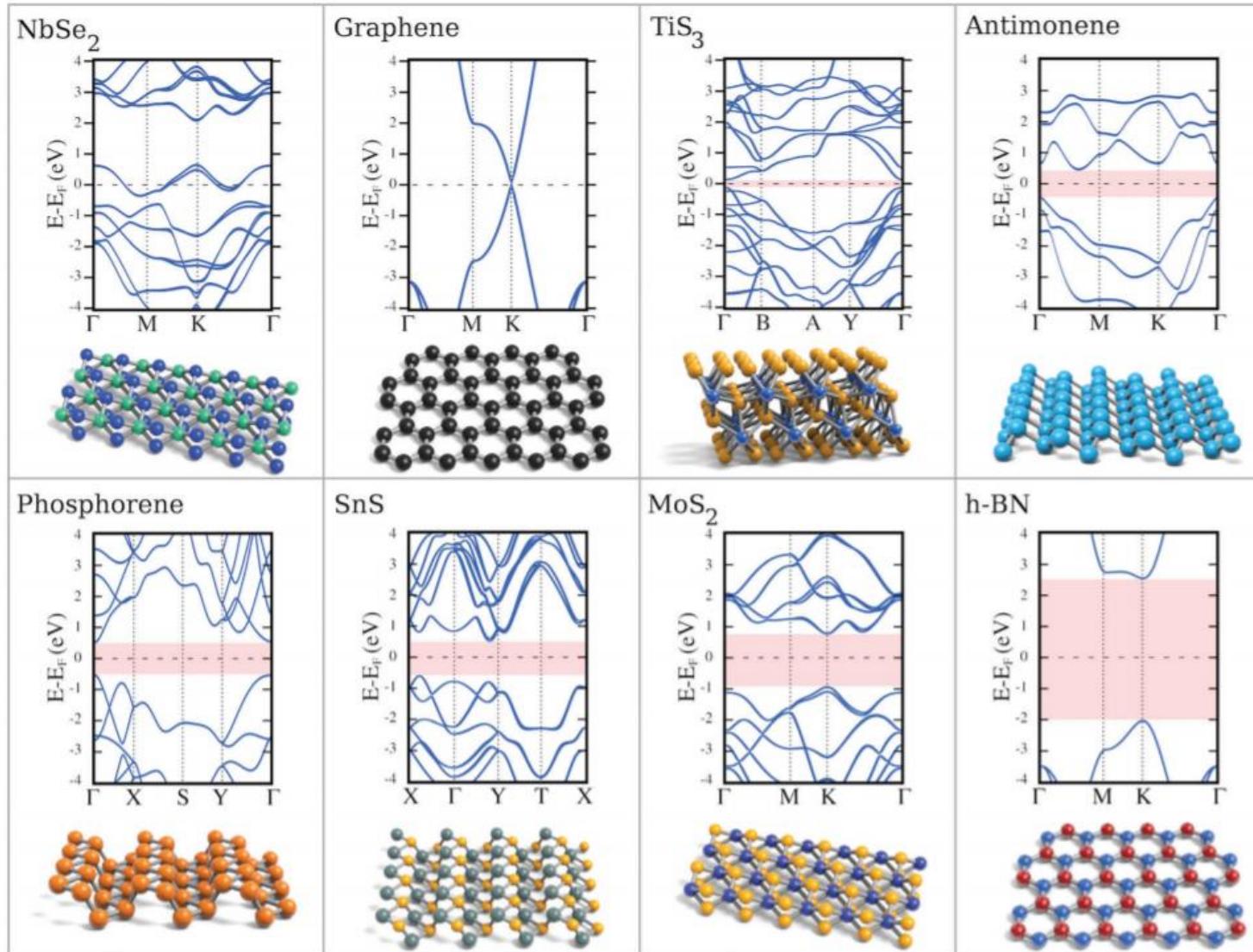
F.Liu et al. Science, 367 (2020)

VdW Materials = 2D Crystals

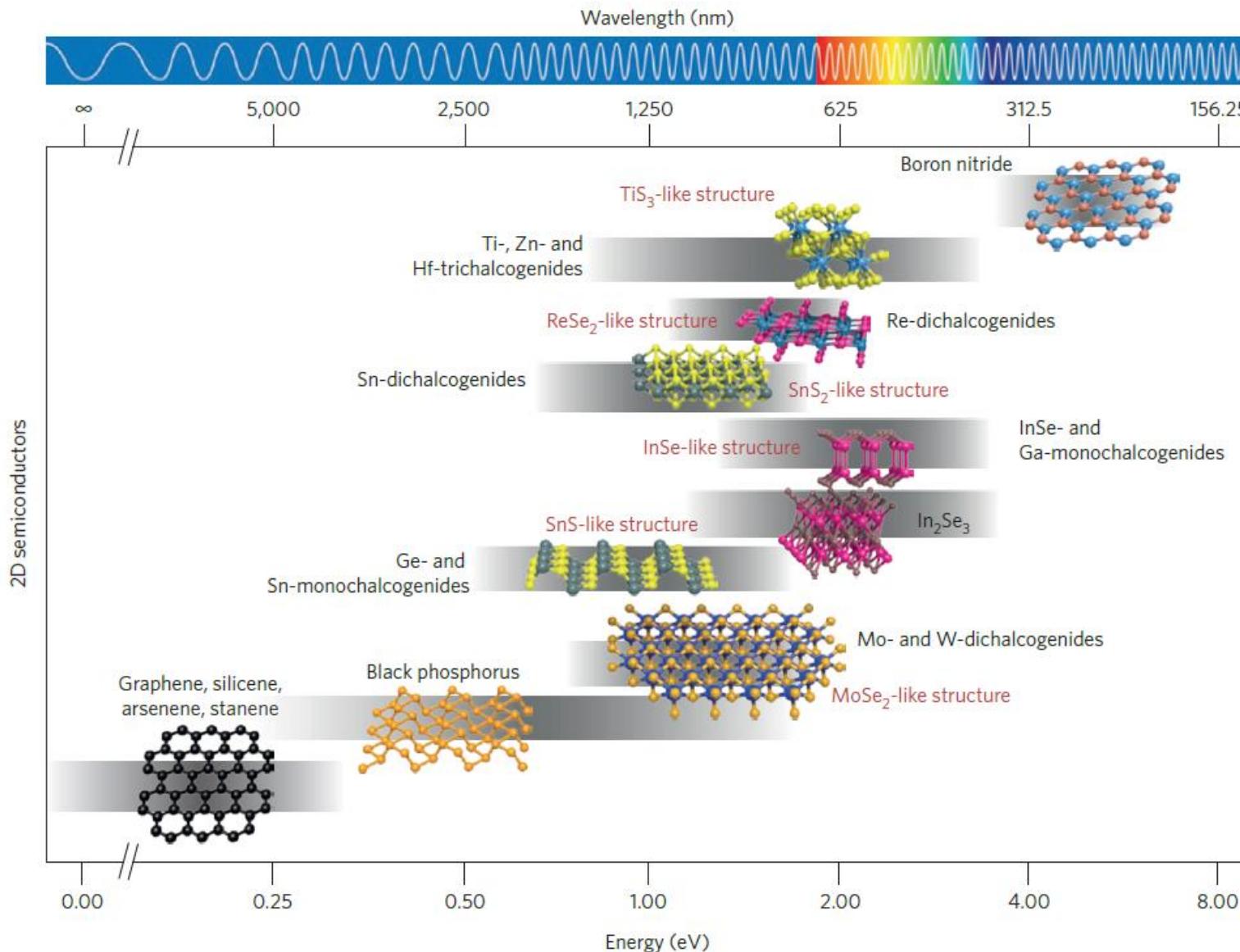
DEFINITION:

Dimensionality is one of the most defining material parameters; the same chemical compound can exhibit dramatically different properties depending on whether it is arranged in a 0D, 1D, 2D, or 3D crystal structure. Although quasi-0D [e.g., cage molecules (1)], quasi-1D [e.g., nanotubes (2-4)], and, of course, 3D crystalline objects are well documented, dimensionality two is conspicuously absent among experimentally known crystals. On the other hand, there are many layered materials with strong in-plane bonds and weak, van der Waals-like coupling between layers. Because of this layered structure, it has long been tempting to try splitting such materials into individual atomic layers, although it remained unclear whether free-standing atomic layers could exist in principle [thin films become thermodynamically unstable (decompose or segregate) below a certain thickness, typically, of many dozens layers].

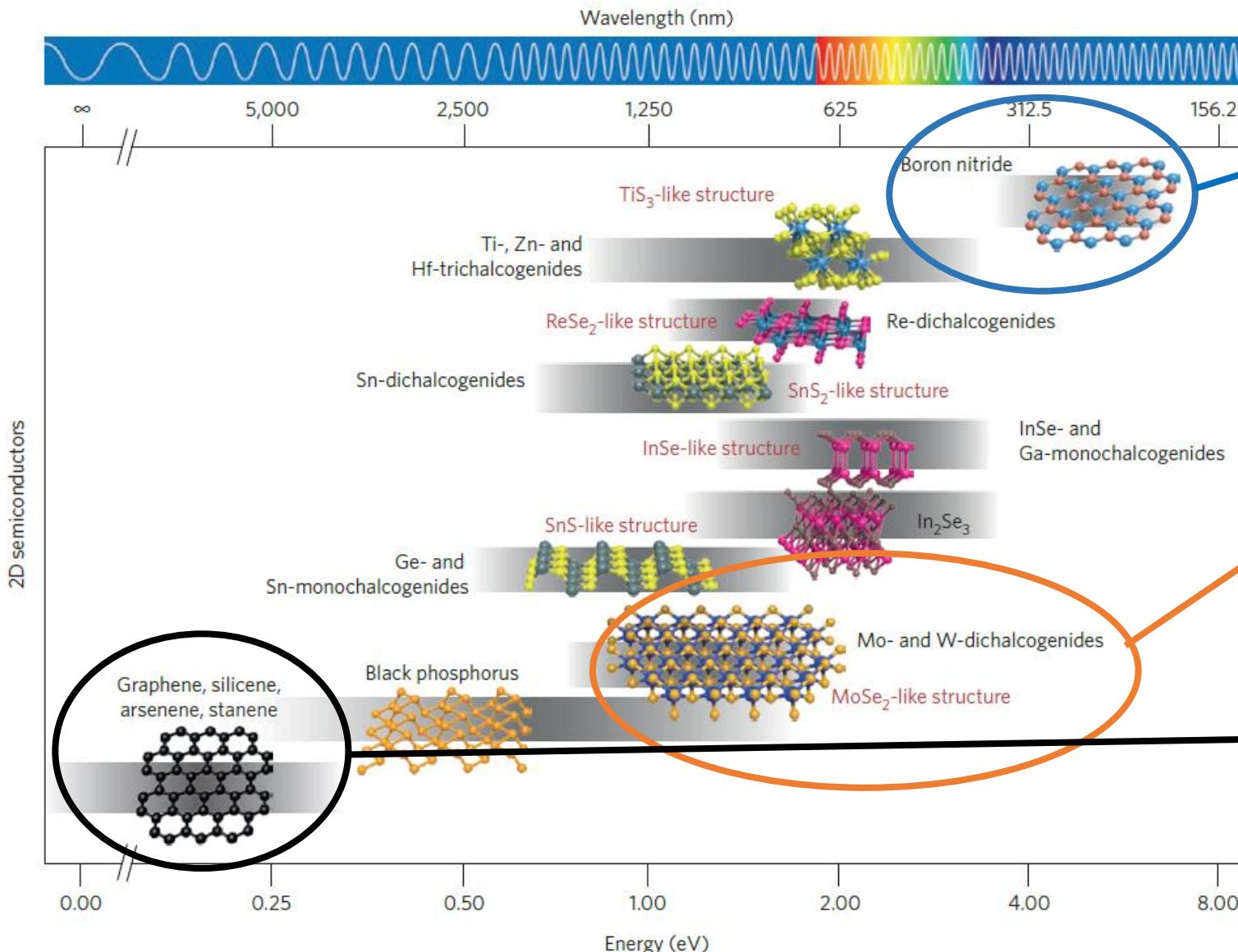
Van der Waals Compounds



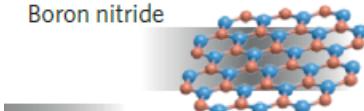
Van der Waals Compounds



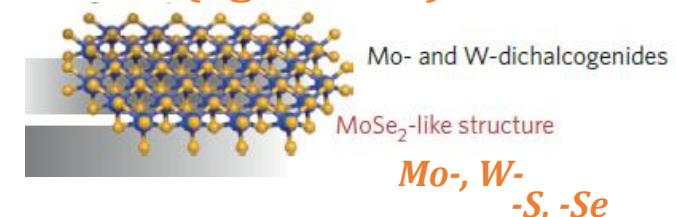
Van der Waals Compounds



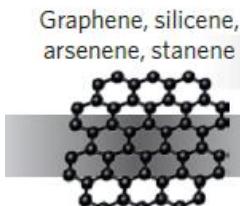
Boron Nitride (BN)
($E_g \sim 4$ eV)



Transition Metal Dichalcogenides
($E_g \sim 1-2$ eV)

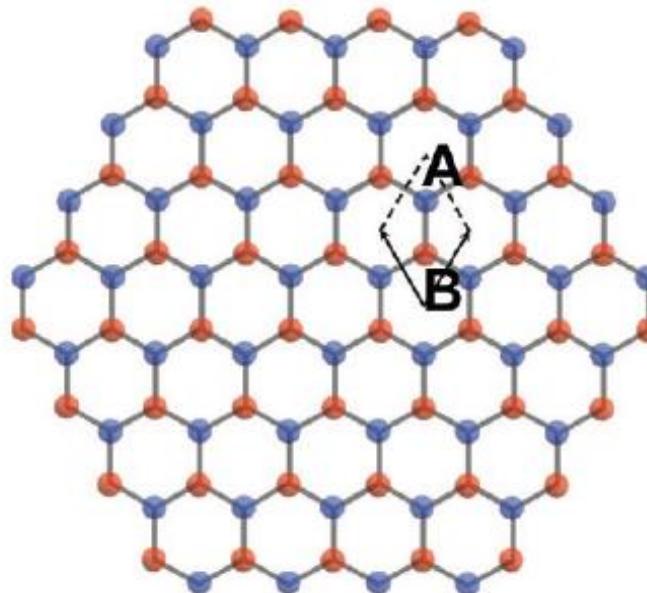


Graphene



Crystal structure (1)

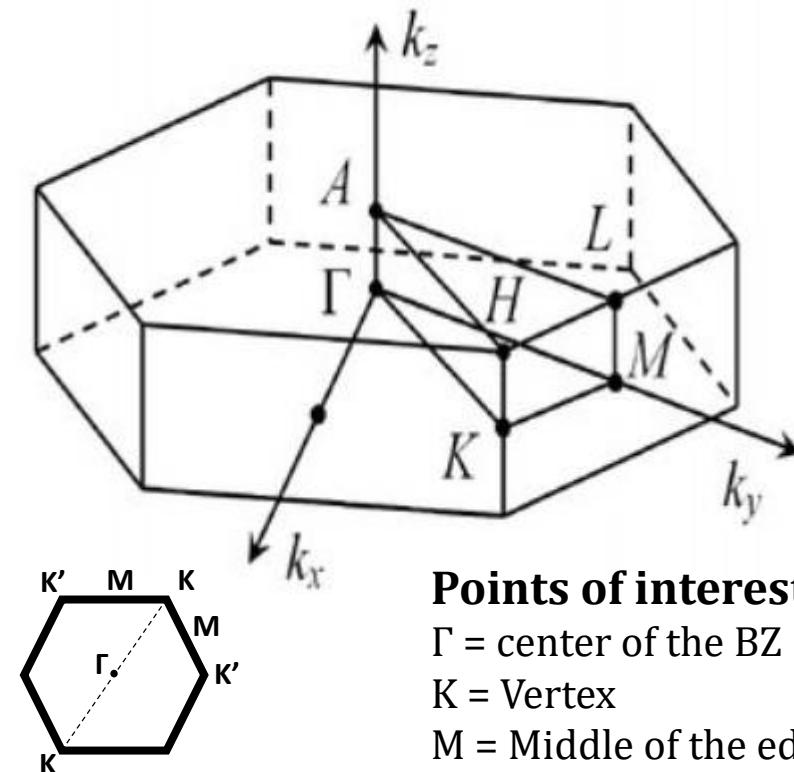
Planar atomic layer = sp^2 hybridization = hexagonal lattice



Graphene
(atomic compound)

BN^*
(bi-atomic compound)

Brillouin Zone



Points of interest

Γ = center of the BZ

K = Vertex

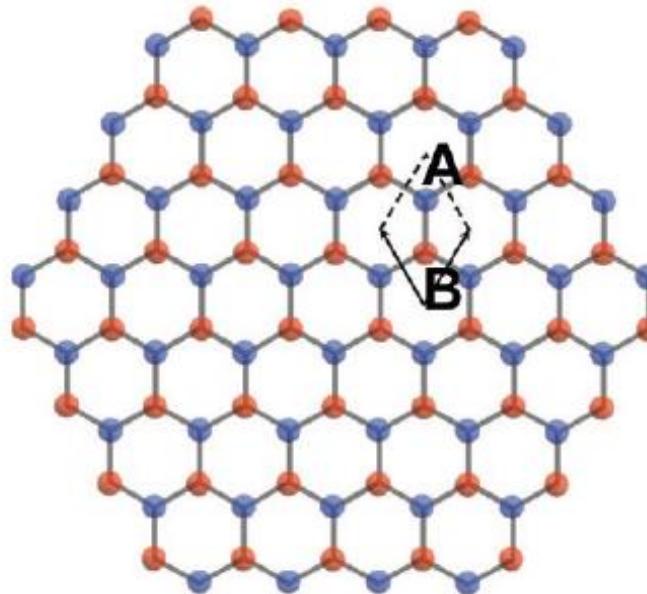
M = Middle of the edge

K' = asymmetric vertex

* Additional 3D phases exist, such as cubic BN (sp^3 hybridization). To differentiate the phases, the 2D crystal is often named «h-BN»

Crystal structure (1)

Planar atomic layer = sp^2 hybridization = hexagonal lattice

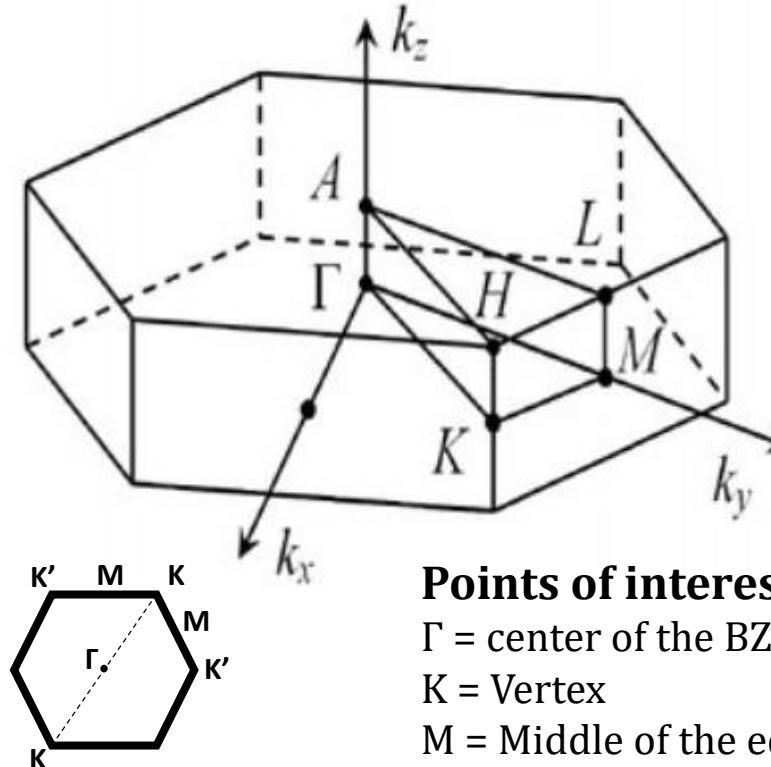


Graphene
(atomic compound)

BN*
(bi-atomic compound)

Avouris, NanoLetter, 10, (2010)

Which of these
compounds
present a K'
point in its BZ?



Brillouin Zone

Points of interest
 Γ = center of the BZ
K = Vertex
M = Middle of the edge
 K' = asymmetric vertex

* Additional 3D phases exist, such as cubic BN (sp^3 hybridization).
To differentiate the phases, the 2D crystal is often named «h-BN»

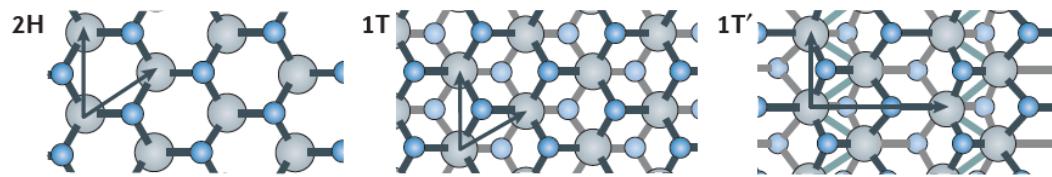
Crystal structure (2)

Transition Metal Dichalcogenides (TMDs)

Formula: MX_2

M = Metal (W, Mo, Nb, Ti...)
X = Chalcogen (S, Se or Te)

Lattice depends on the coordination of the metal atom.



Transition metal Chalcogen

Trigonal prismatic

Octahedral

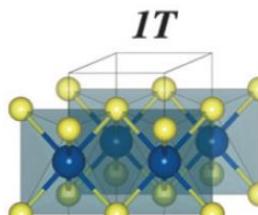
Dimerized

1T, 2H, 3R

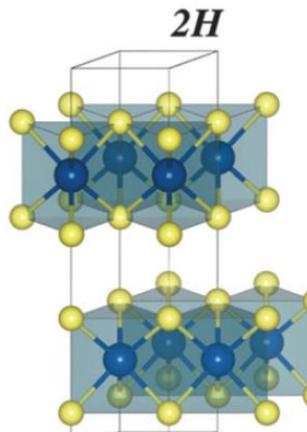
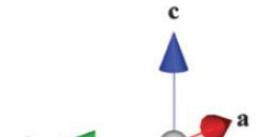
Number of layers in the unit

+

Letter denotes the symmetry



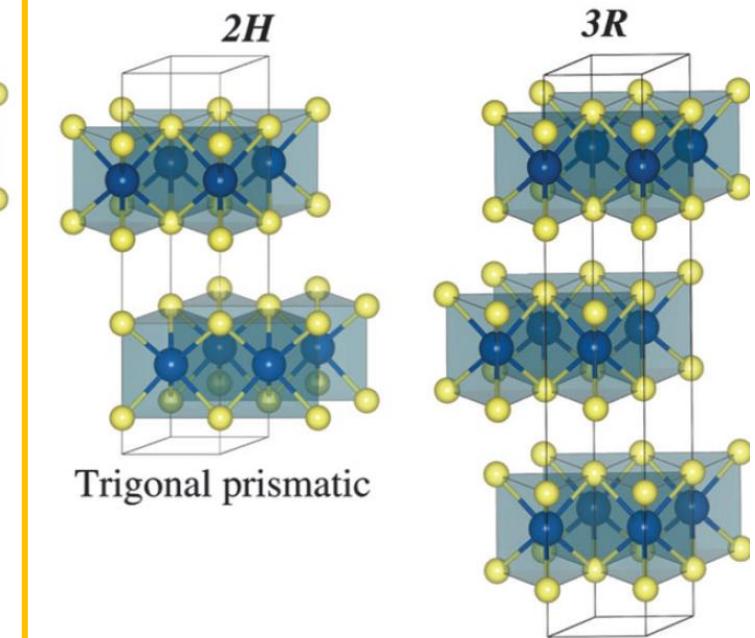
Octahedral



Trigonal prismatic

a
b
c
X
T

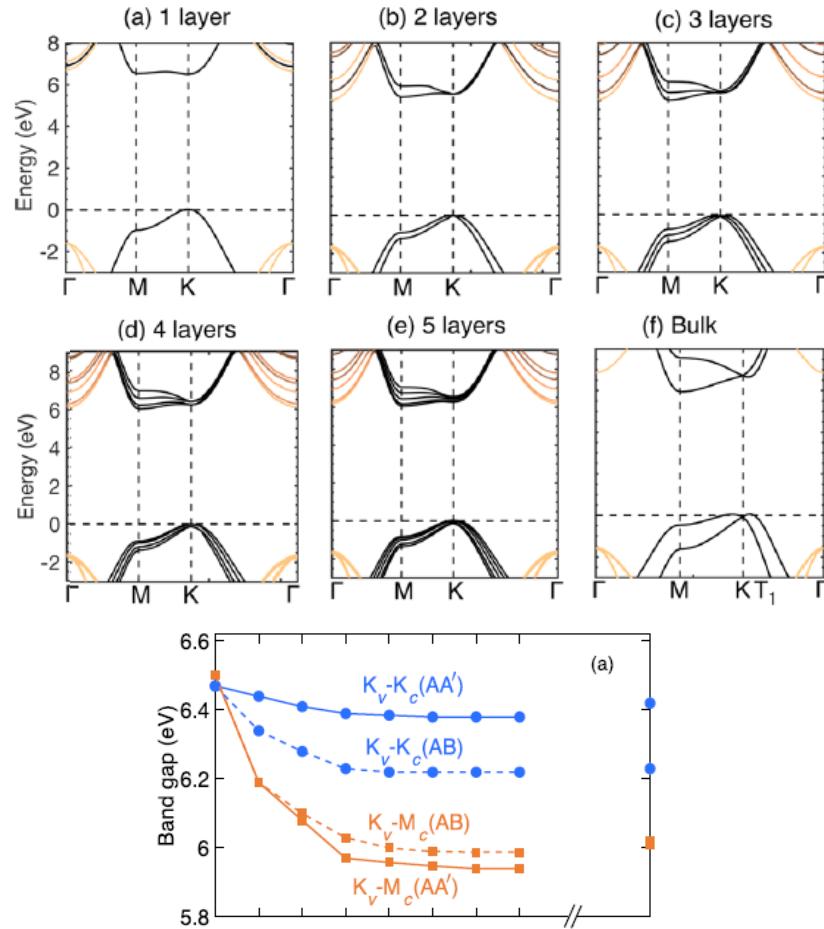
(Hexagonal Lattice)



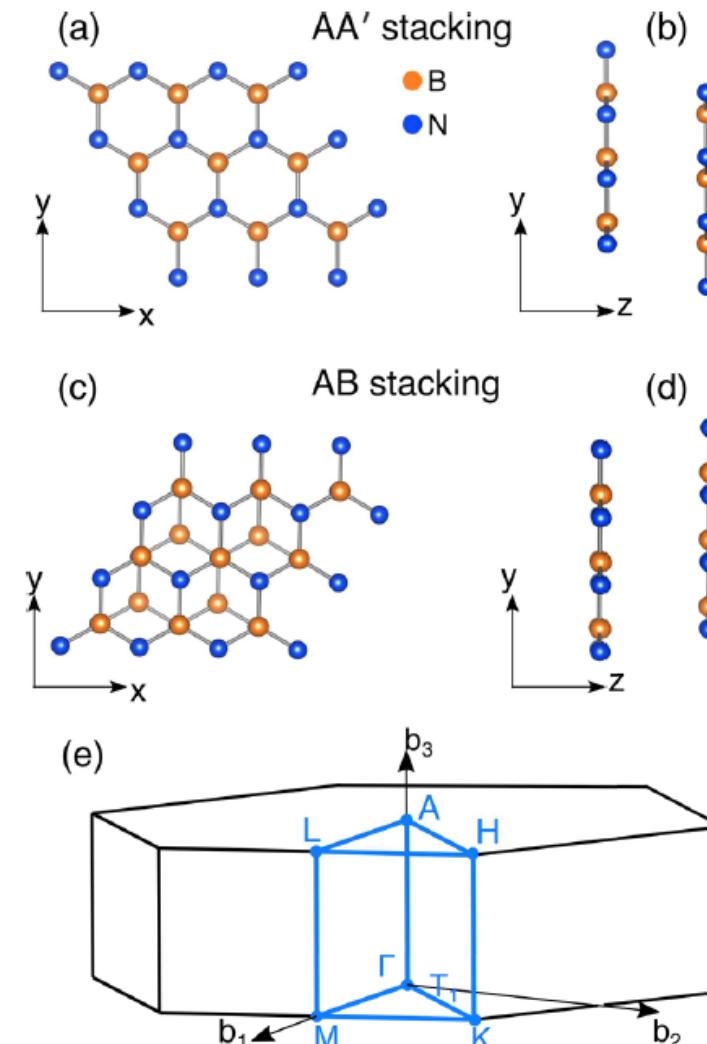
Thermodynamically Trigonal prismatic
Stable Phases for: MoS_2 WS_2
 $MoSe_2$ WSe_2

Unique Features

Layer-dependance

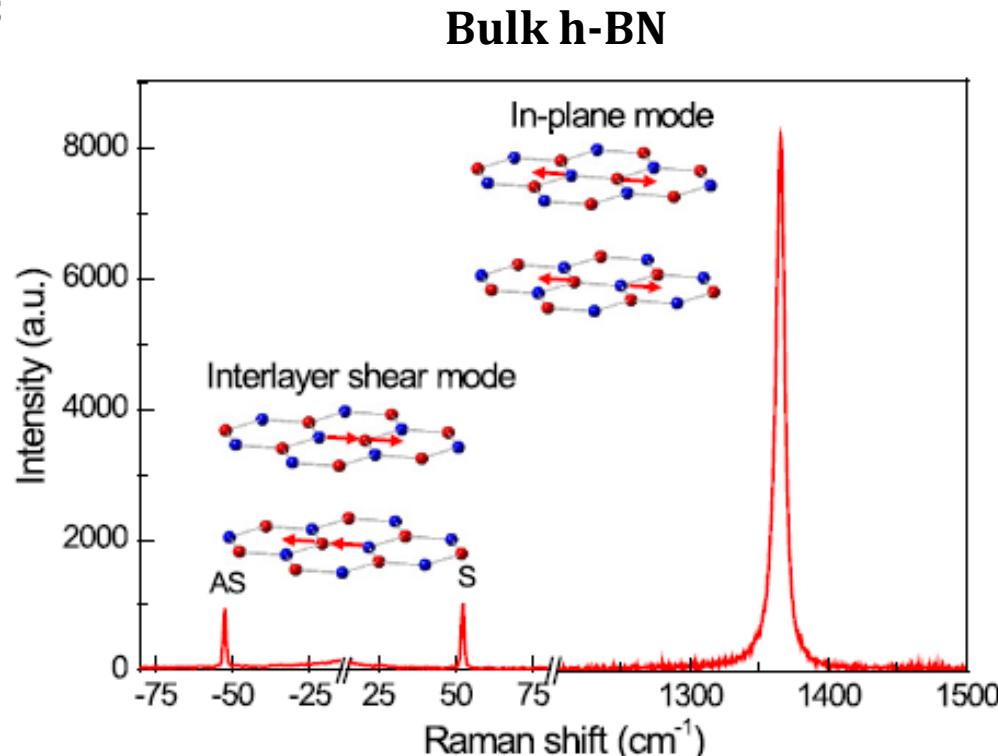
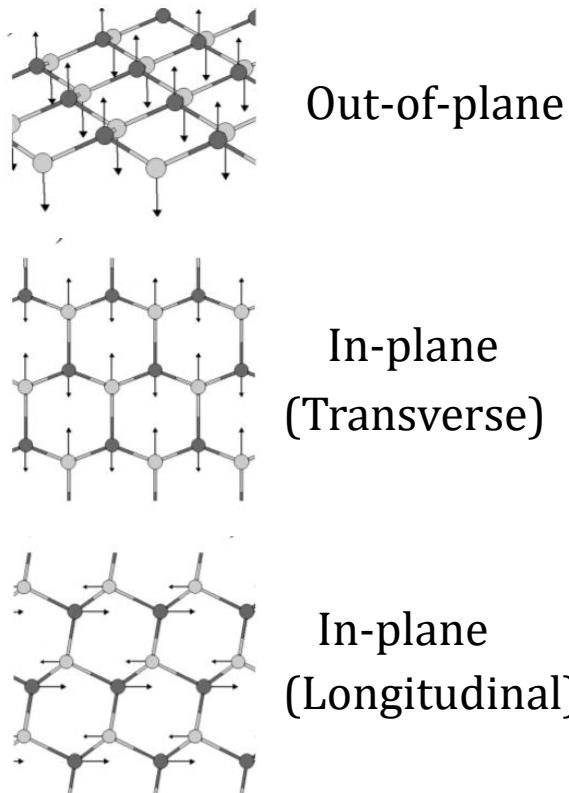


Sequencing

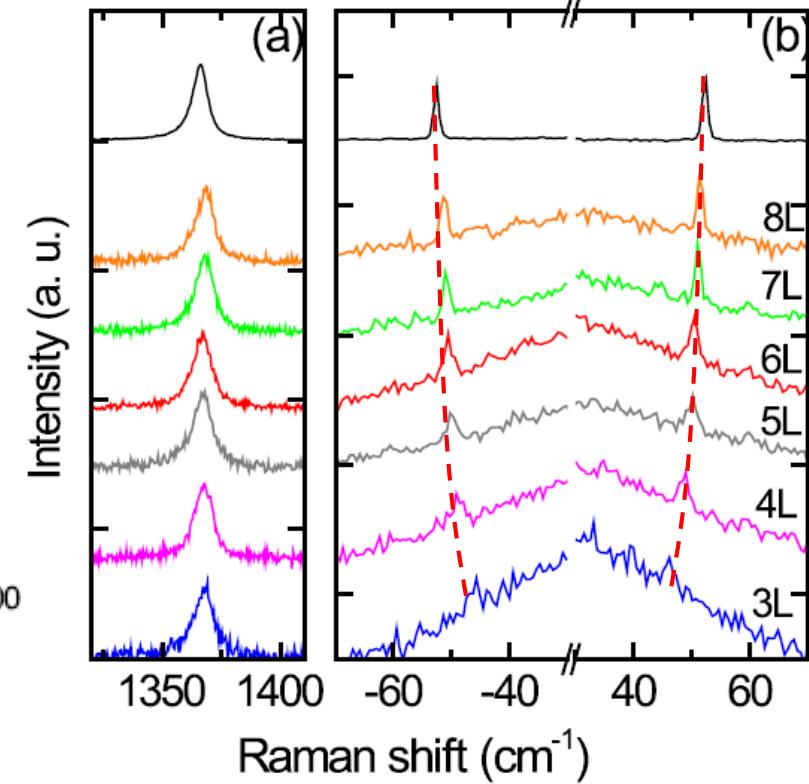


Bulk to monolayer: lattice vibration

Example of vibrational modes (h-BN)



Decreasing number of layers (L)

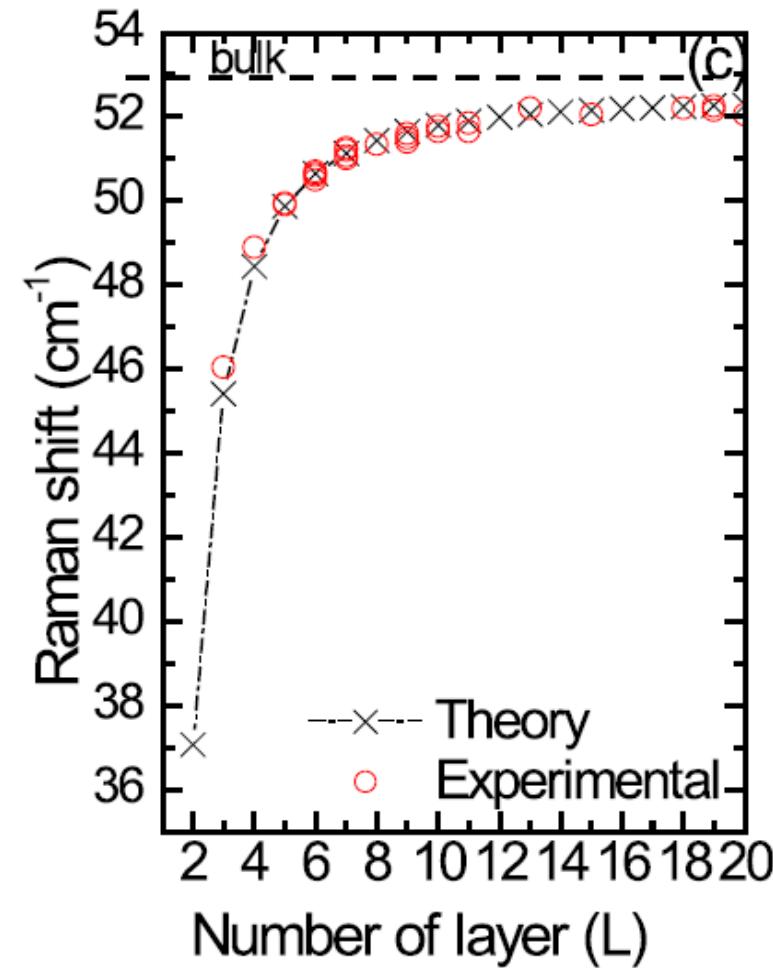
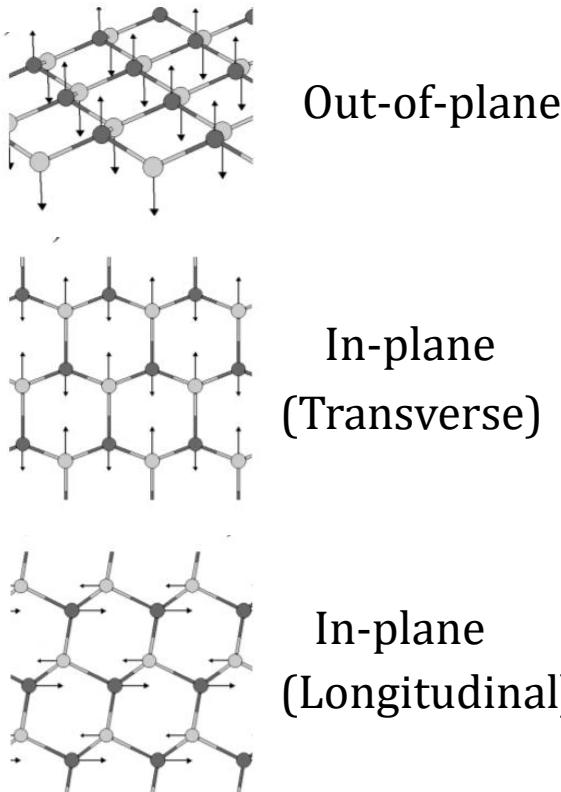


No significant variation on in-plane mode Raman peak at $\sim 1350 \text{ cm}^{-1}$

Significant shift of the shear mode Raman peak at $\sim 50 \text{ cm}^{-1}$

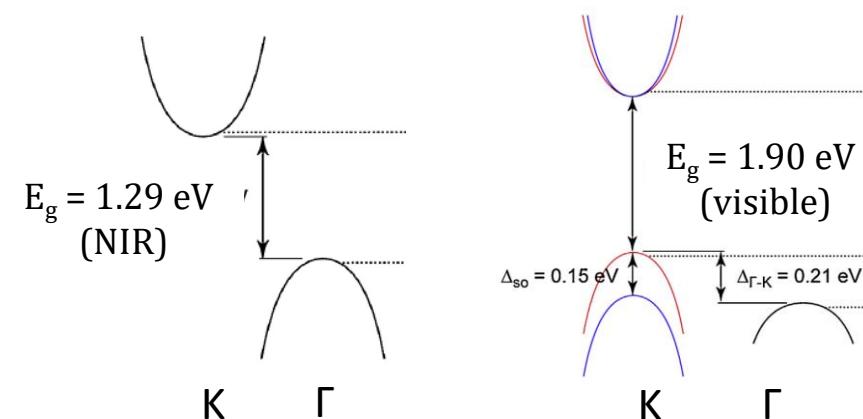
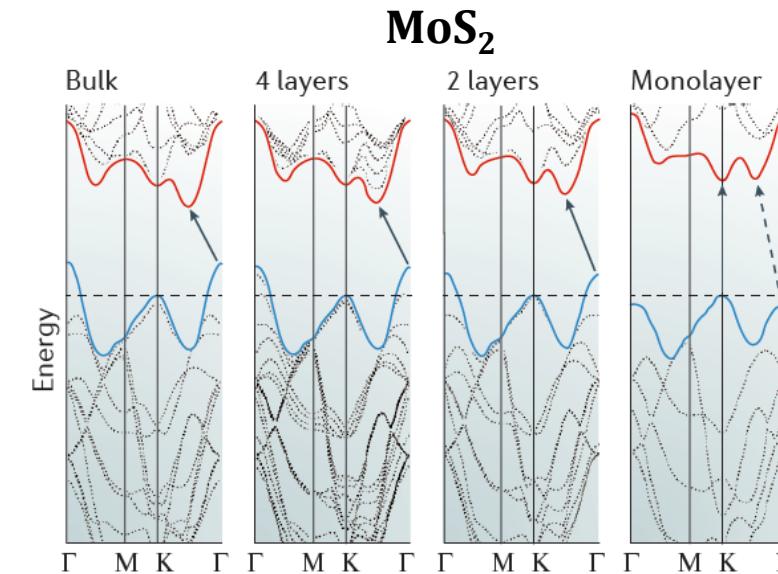
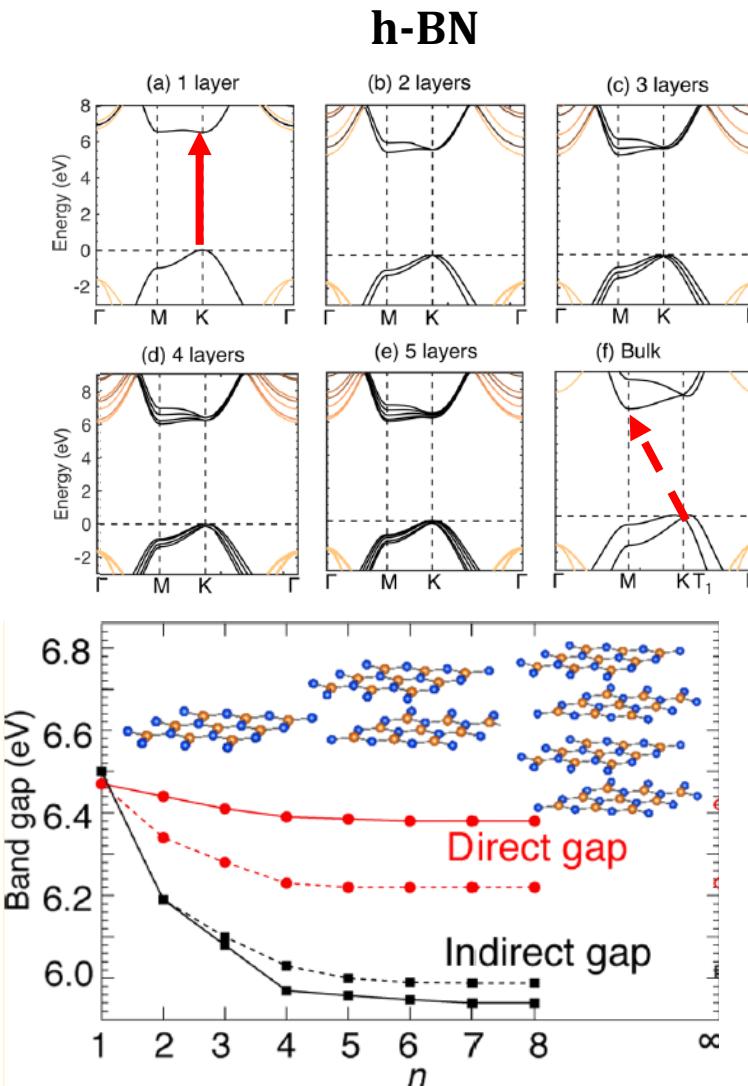
Bulk to monolayer: lattice vibration

Example of vibrational modes (h-BN)



Theoretical estimation is done through a linear chain model (each layer interacts only with the adjacent ones)

Bulk to monolayer: band structure (1)

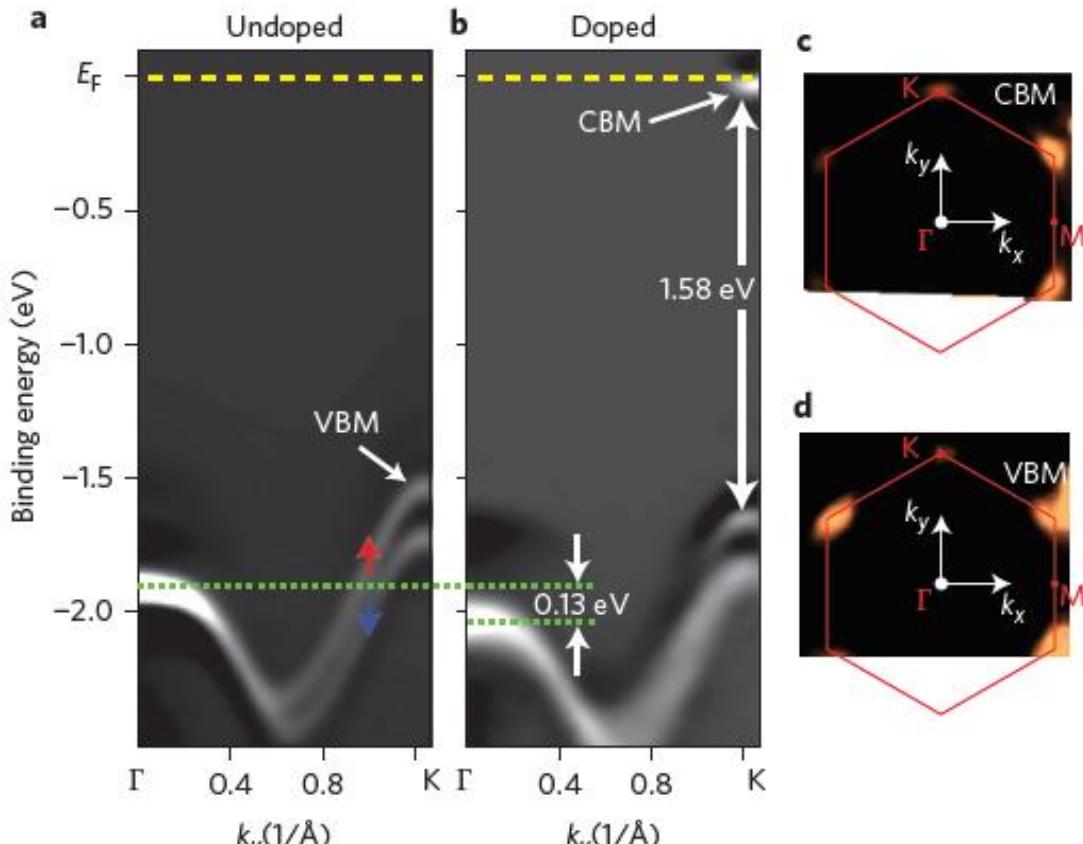


Wickramaratne et al. J. Phys. Chem. C, 122, (2018)

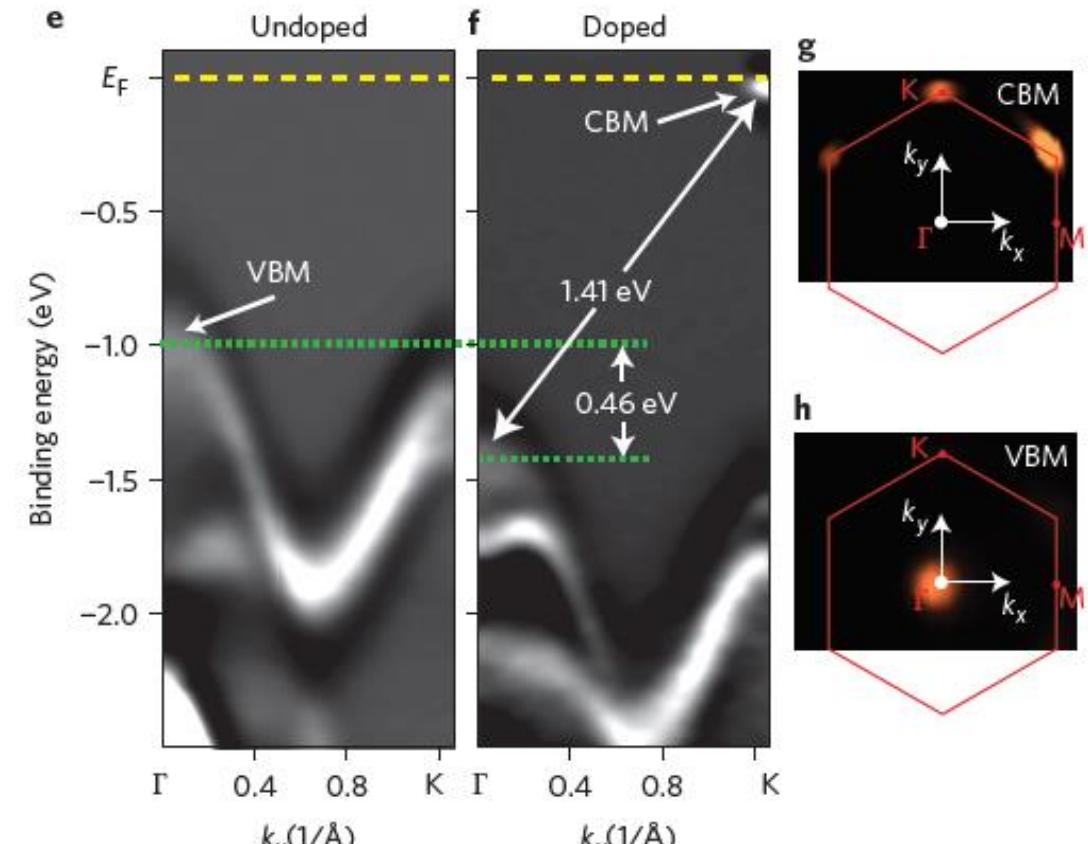
Manzeli et al., Nature Reviews, 2, (2017)
Yazyev, A. Kis, Mater. Today, 18, (2014)

Bulk to monolayer: band structure (2)

Angle Resolved PhotoEmission Spectroscopy (ARPES)

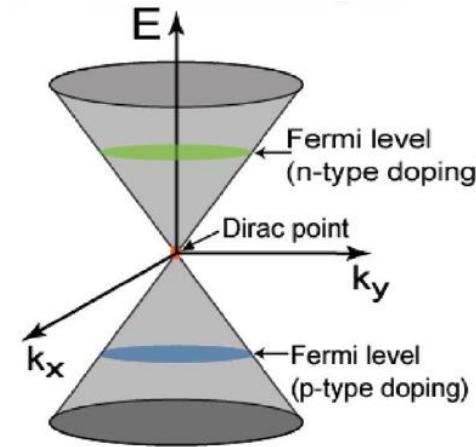
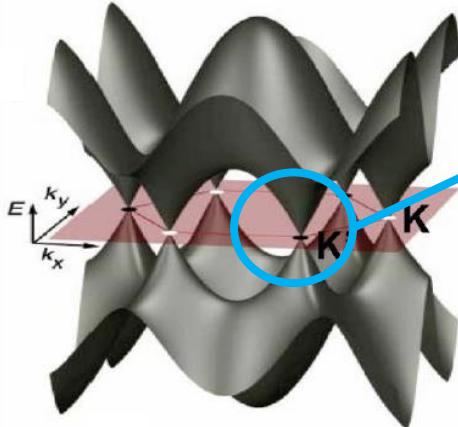
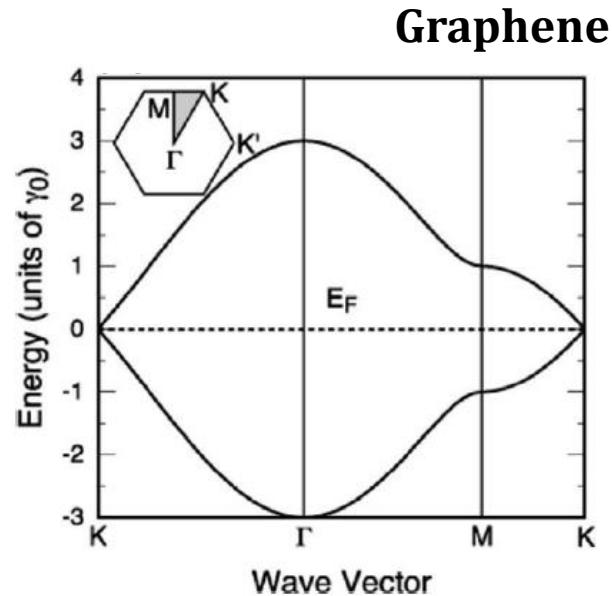


1 ML - MoSe₂

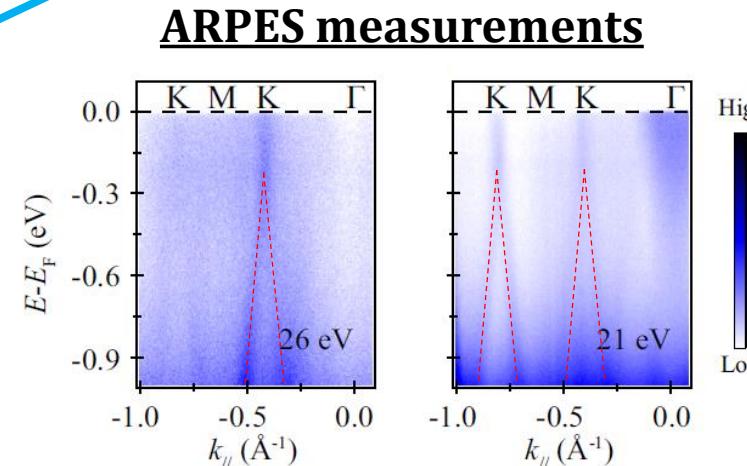


8 ML - MoSe₂

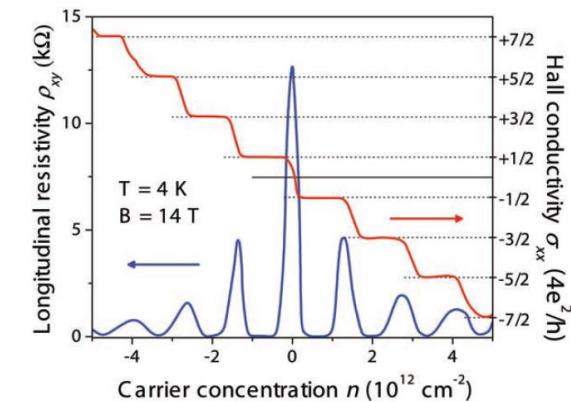
Bulk to monolayer: band structure (3)



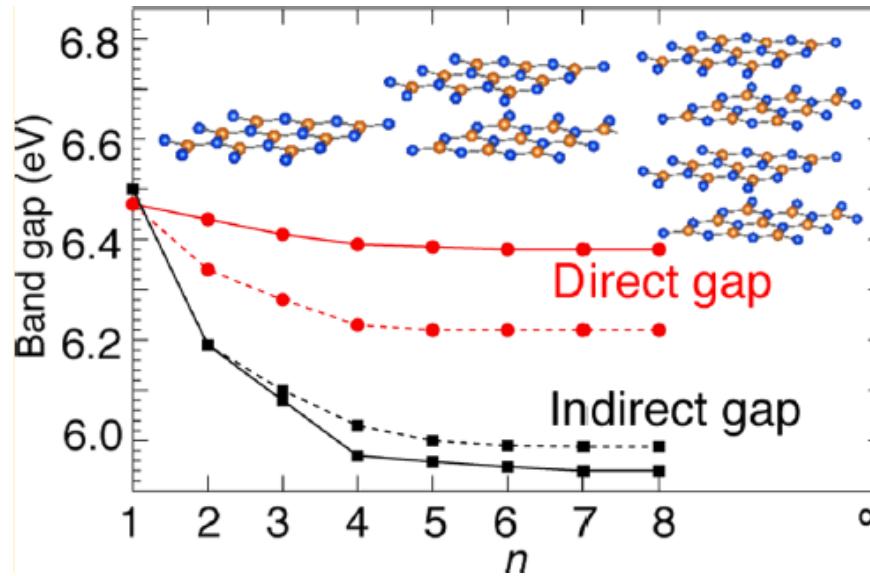
DIRAC CONE:
Linear energy – momentum
relationship (E-k)



QHE in Dirac Cones



Exercise (10 minutes)



Why in 2D crystals the band gap is decreasing with increasing number of layers?

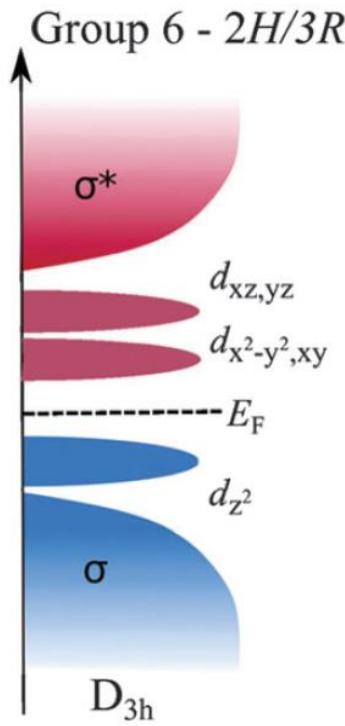
Why are there 4 curves to indicate direct and indirect band gaps of h-BN?

Exercise (5 minutes)

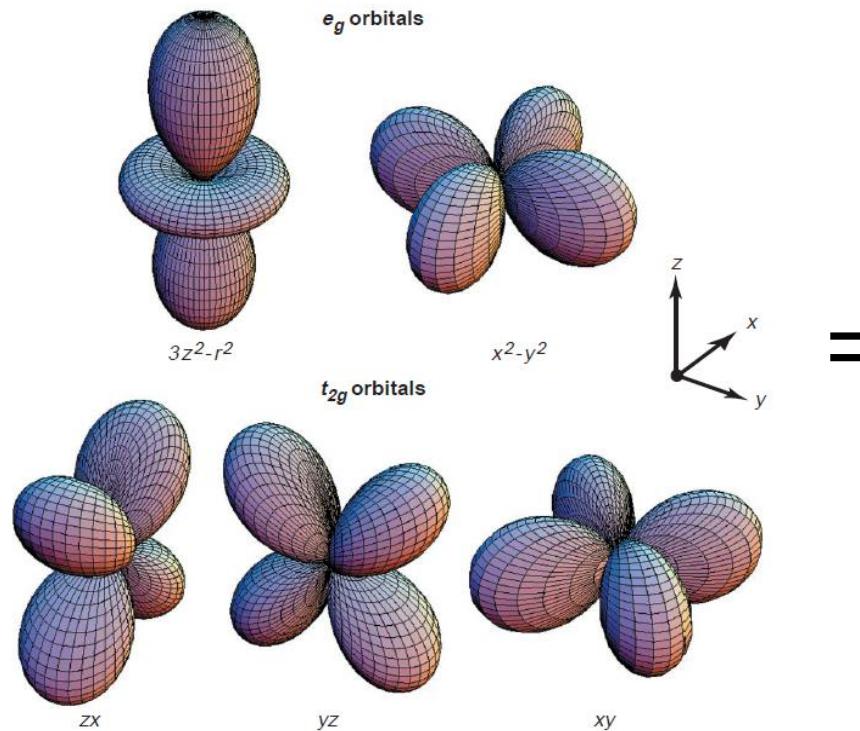
To be solved in Class

Effect of spin-orbit interaction on energy bands

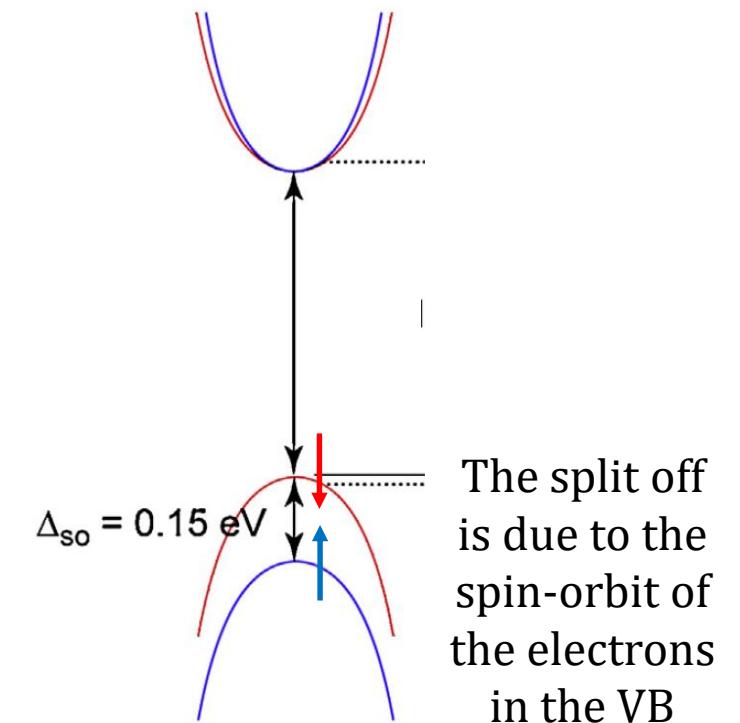
Conduction and Valence band lower levels consists of d-orbitals



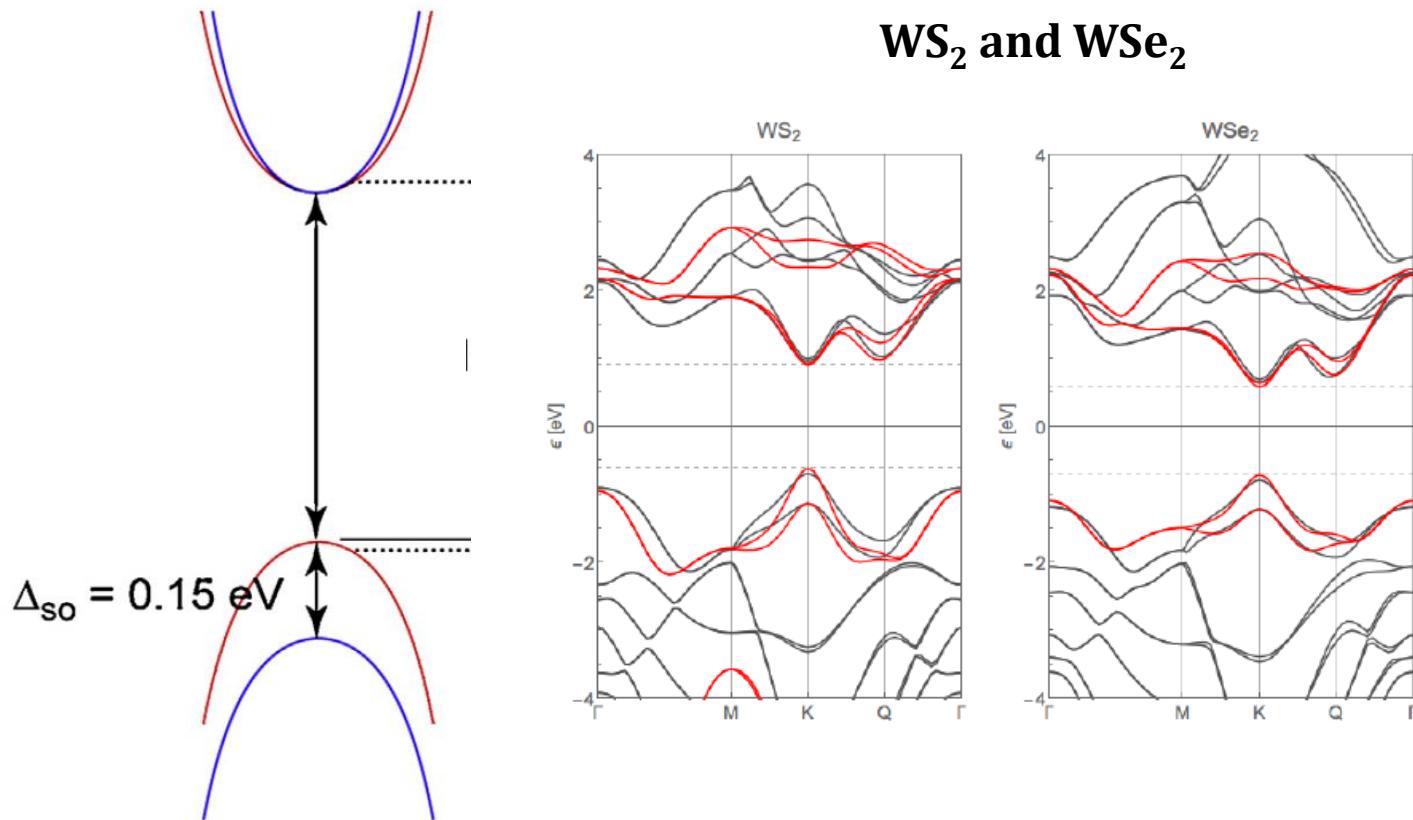
D-orbitals have a high angular momentum



Valence band split off



From spin-orbit interaction to spintronic

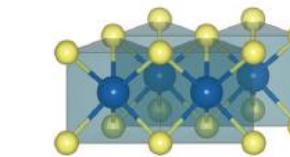
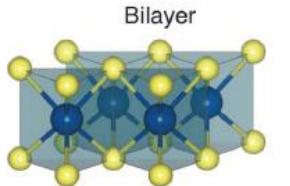
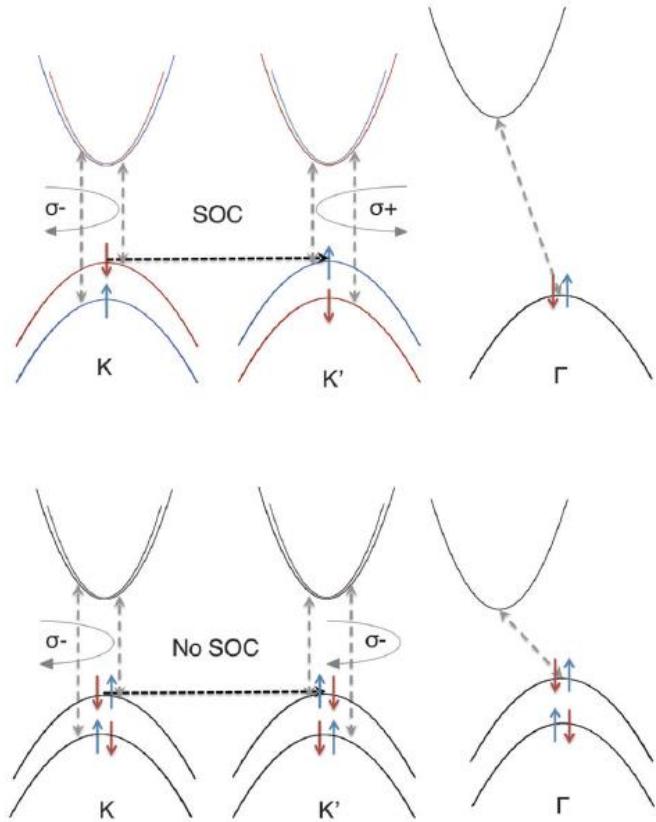
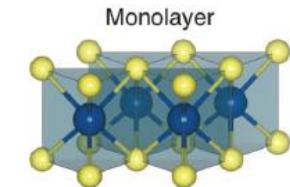


Spintronic: engineering spin split-off by applying external electric and magnetic fields.

Requirement: Materials with high spin-orbit interaction, i.e. materials exhibiting valence split off due to the coupling/decoupling between spin and orbitals

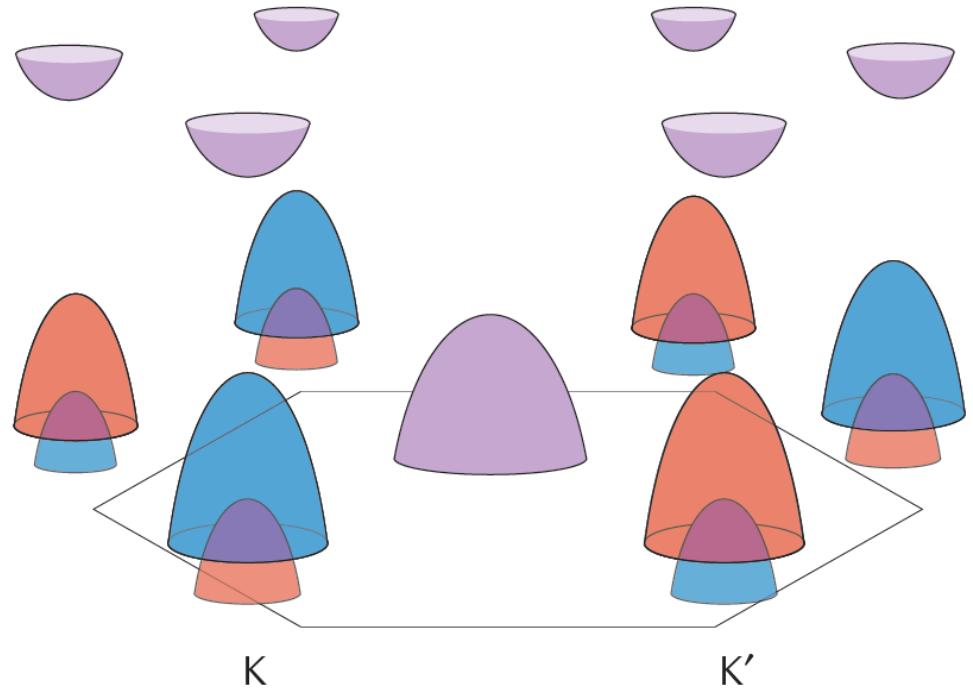
From spintronic to valleytronic

Effect of inversion symmetry on the spin-orbit coupling.



Polarization dependent selection rule for light absorption

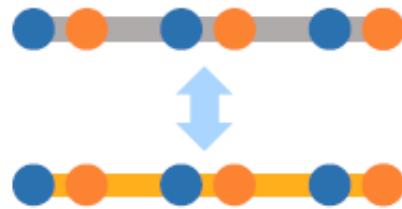
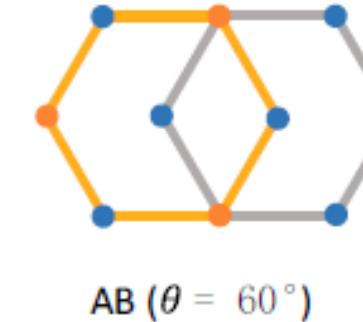
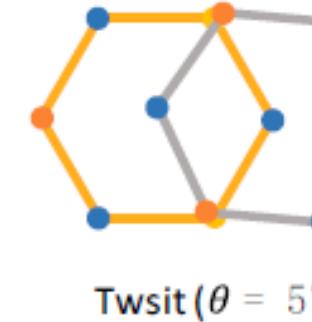
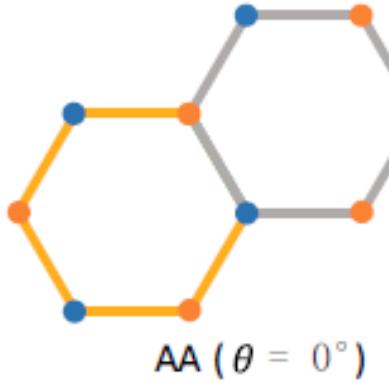
Spin-Valley Locking



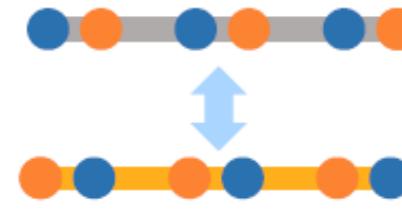
Valleytronic: engineering functional properties on the base of valley-related spin-orbit coupling.

Layer sequencing: 2D stackings

Multi-layer configurations



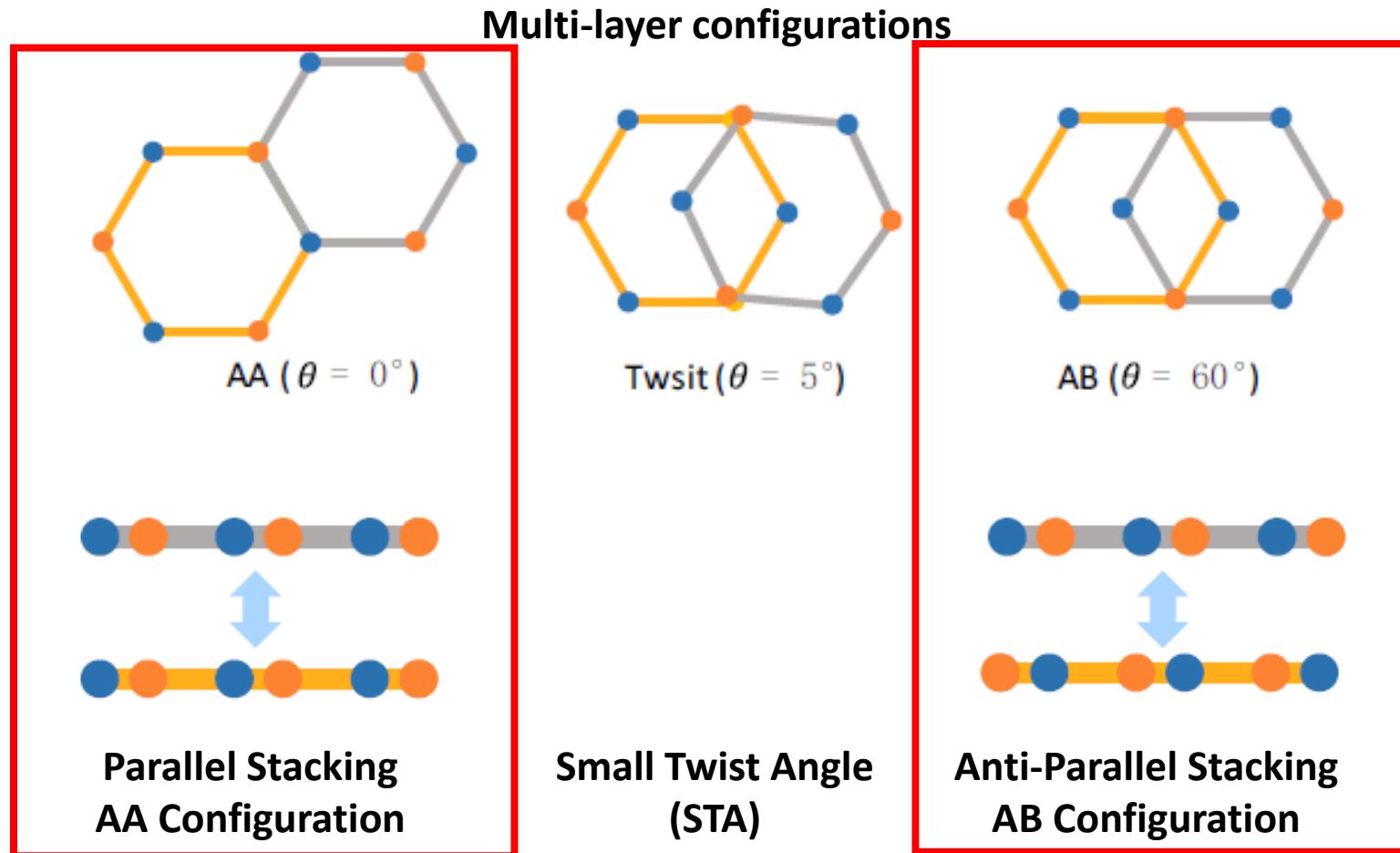
Parallel Stacking
AA Configuration



Small Twist Angle
(STA)

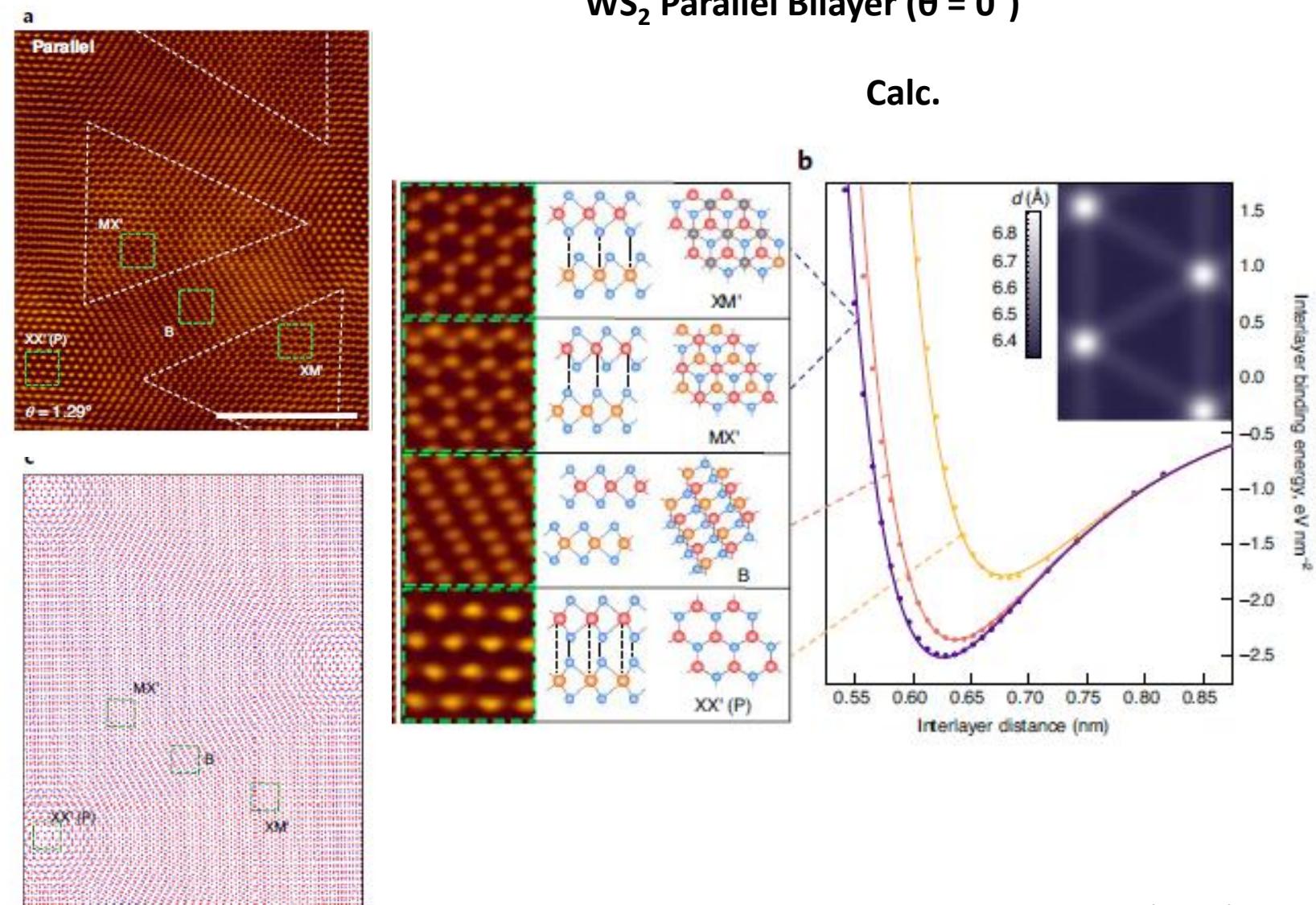
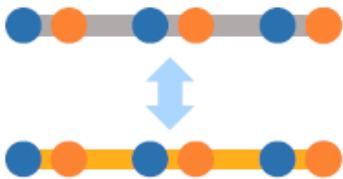
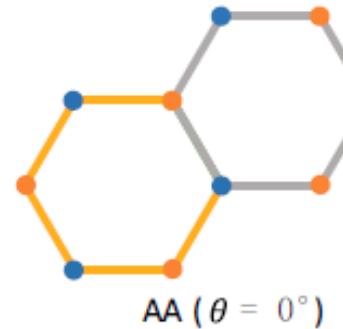
Anti-Parallel Stacking
AB Configuration

Layer sequencing: 2D stackings



Layer sequencing: Parallel Stacking

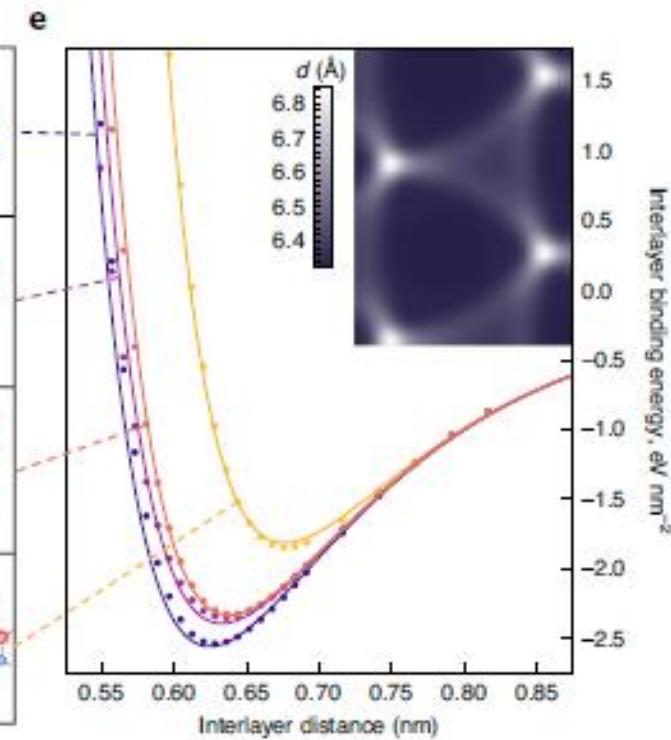
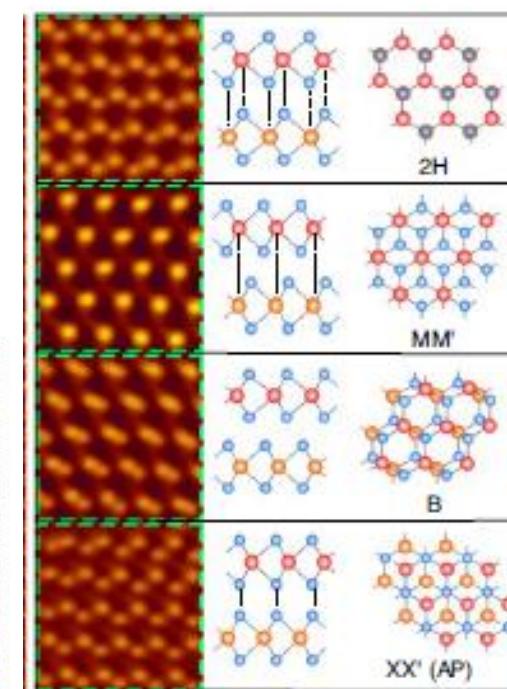
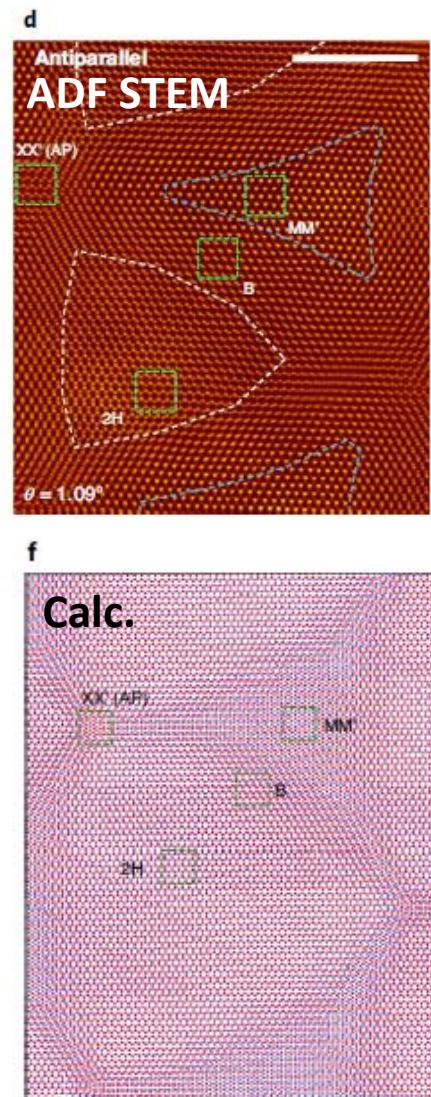
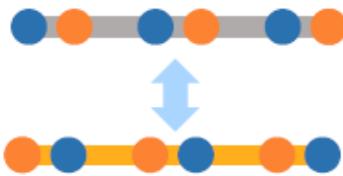
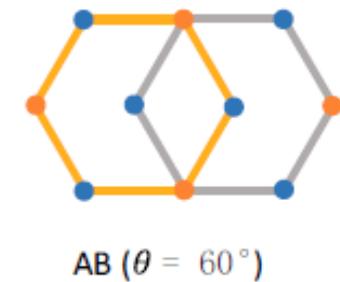
Parallel configuration (AA)



Layer sequencing: Anti-Parallel Stacking

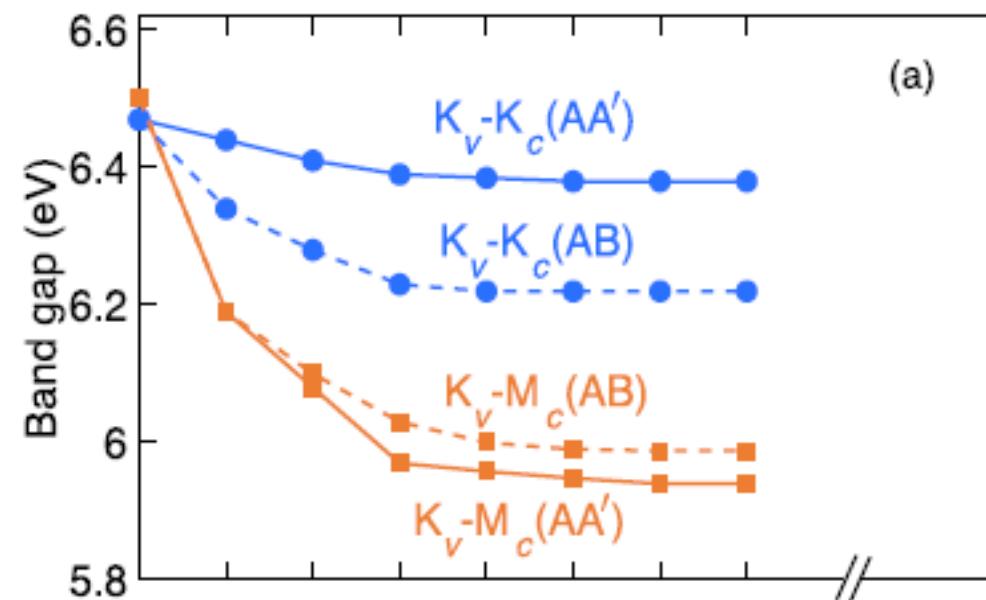
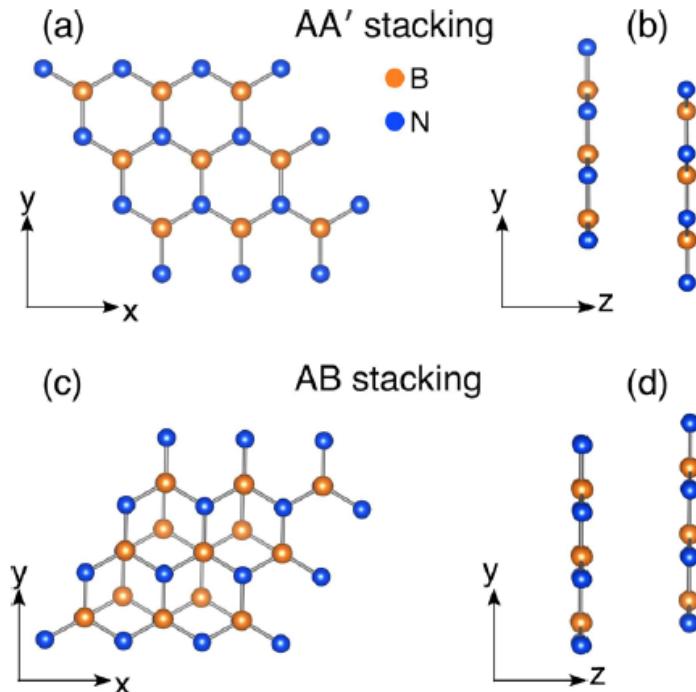
WS₂ Anti-Parallel Bilayer ($\theta = 60^\circ$)

Anti- parallel configurations (AB)



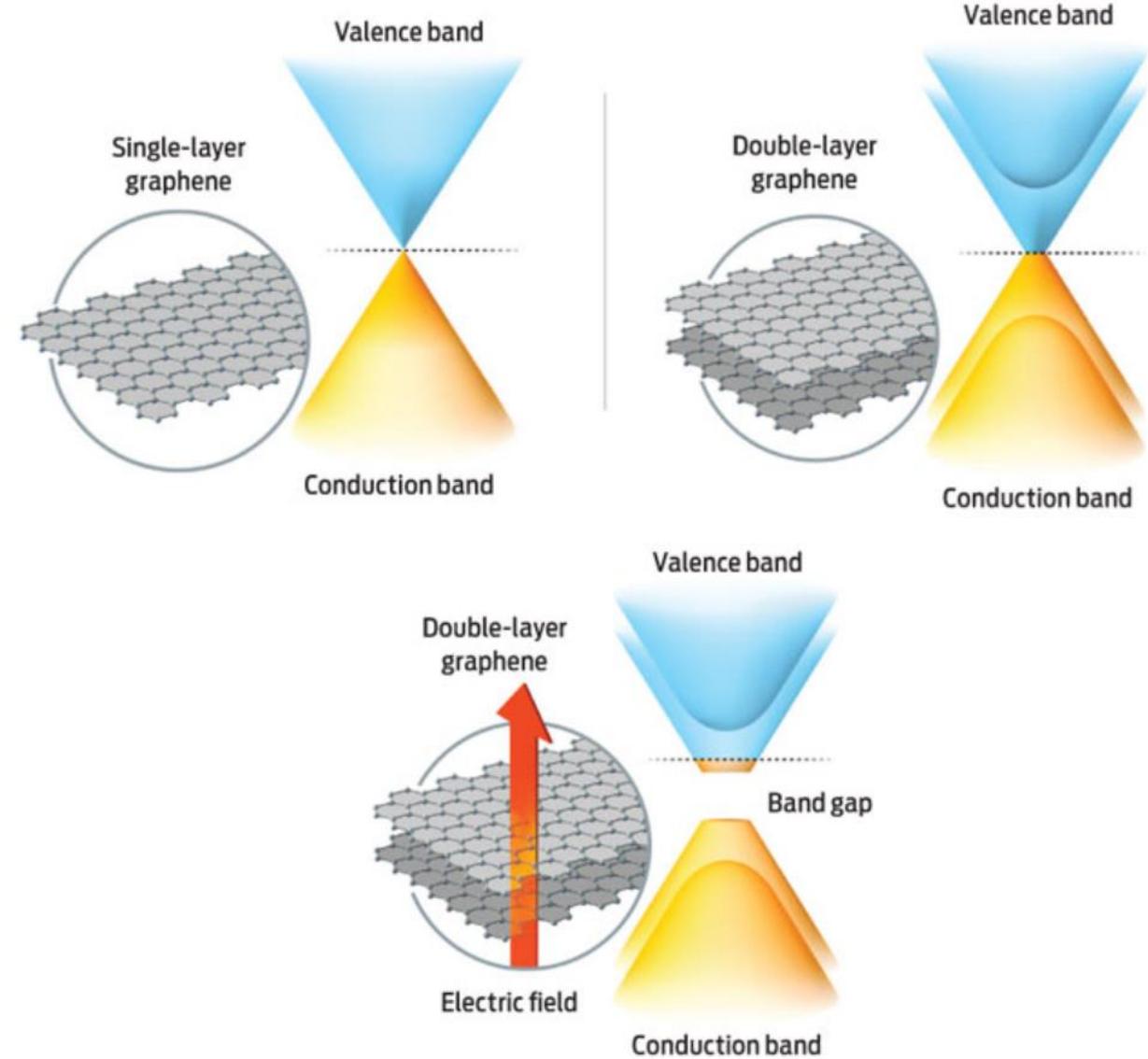
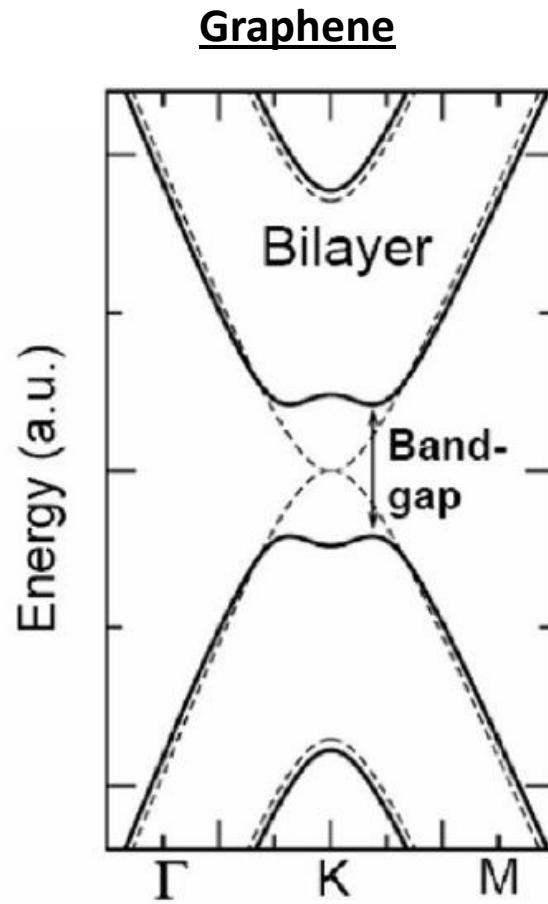
Effect of parallel/anti-parallel stacking (1)

h-BN (previous example)



Since the interlayer distance varies with the stacking sequence, different bandgap are expected for AA' and AB configurations.

Effect of parallel/anti-parallel stacking (2)

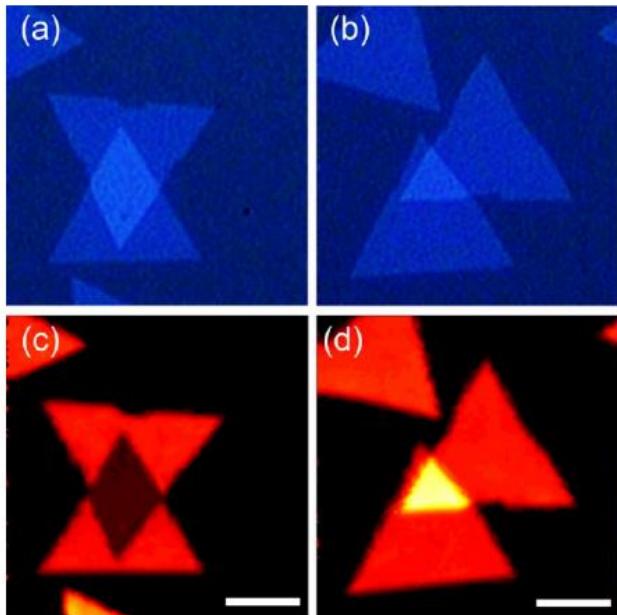


It is possible to open a band-gap in AB bilayer graphene by applying an electric field perpendicular to the layers.

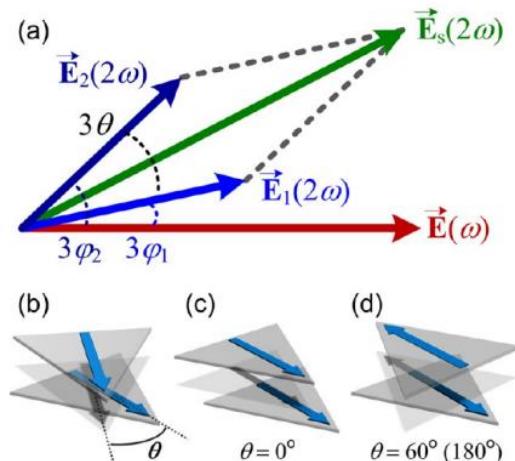
Effect of parallel/anti-parallel stacking (3)

Second Harmonic Generation

Optical microscopy image of MoS₂ flakes



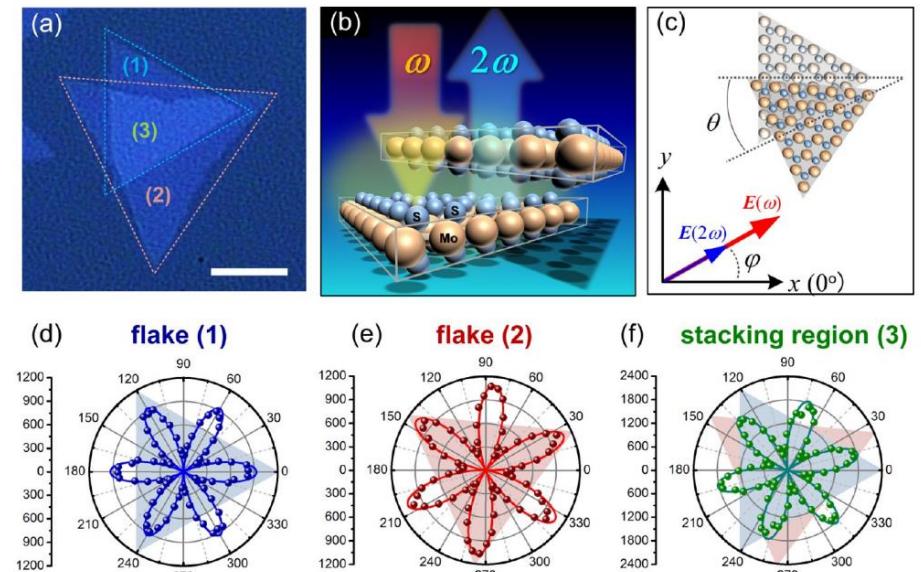
SHG map



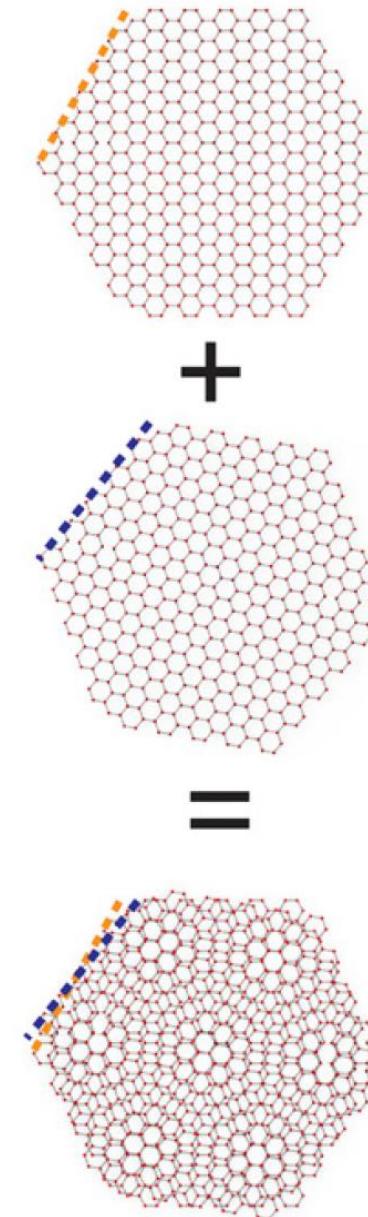
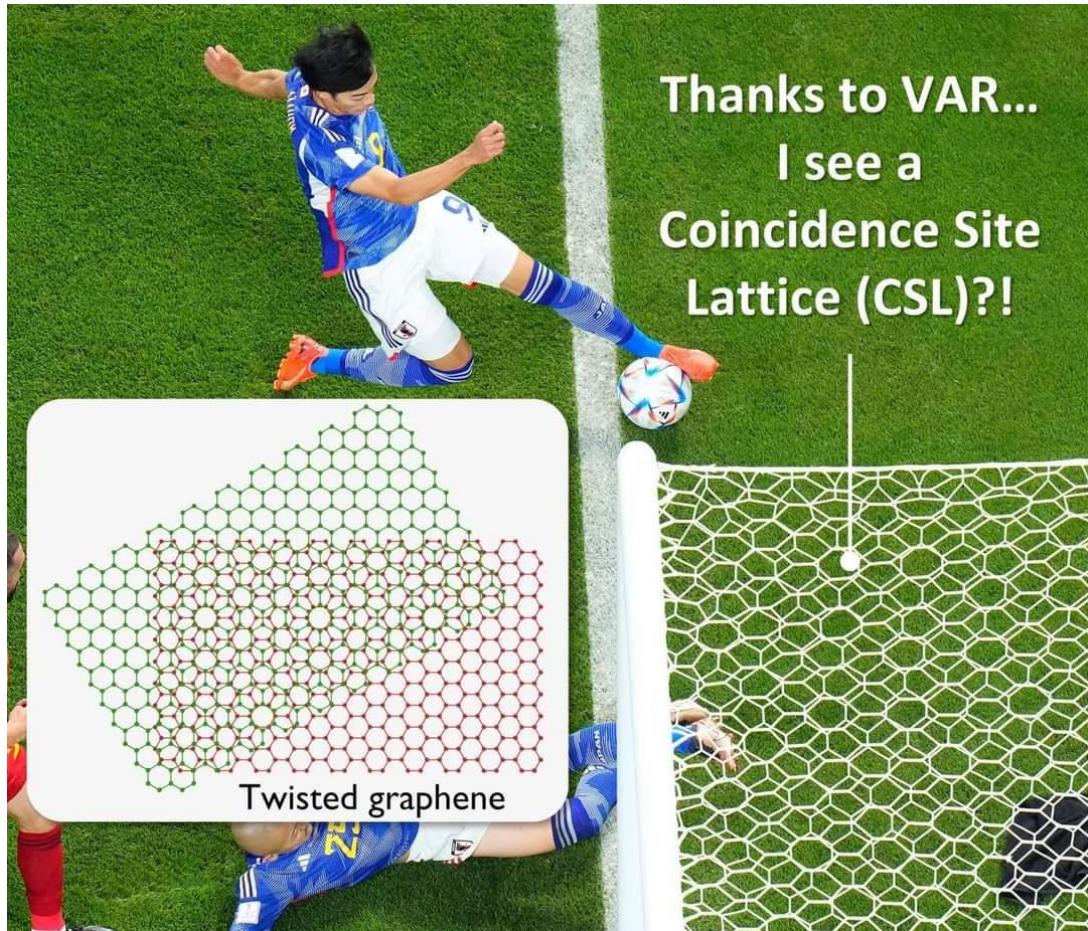
Anti-parallel:
Destructive
interference

Parallel:
Constructive
interference

Polarization of SH from bilayers (Polar plot)

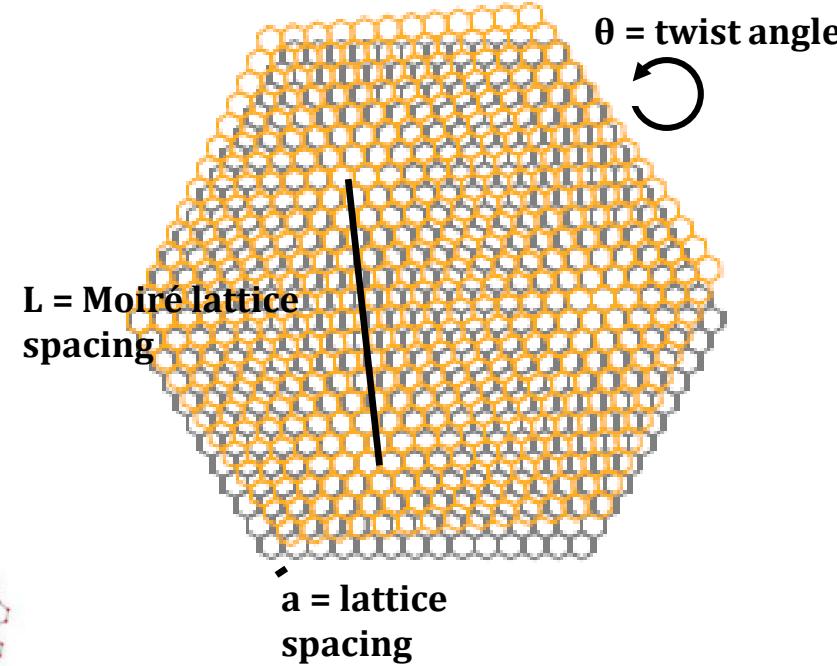
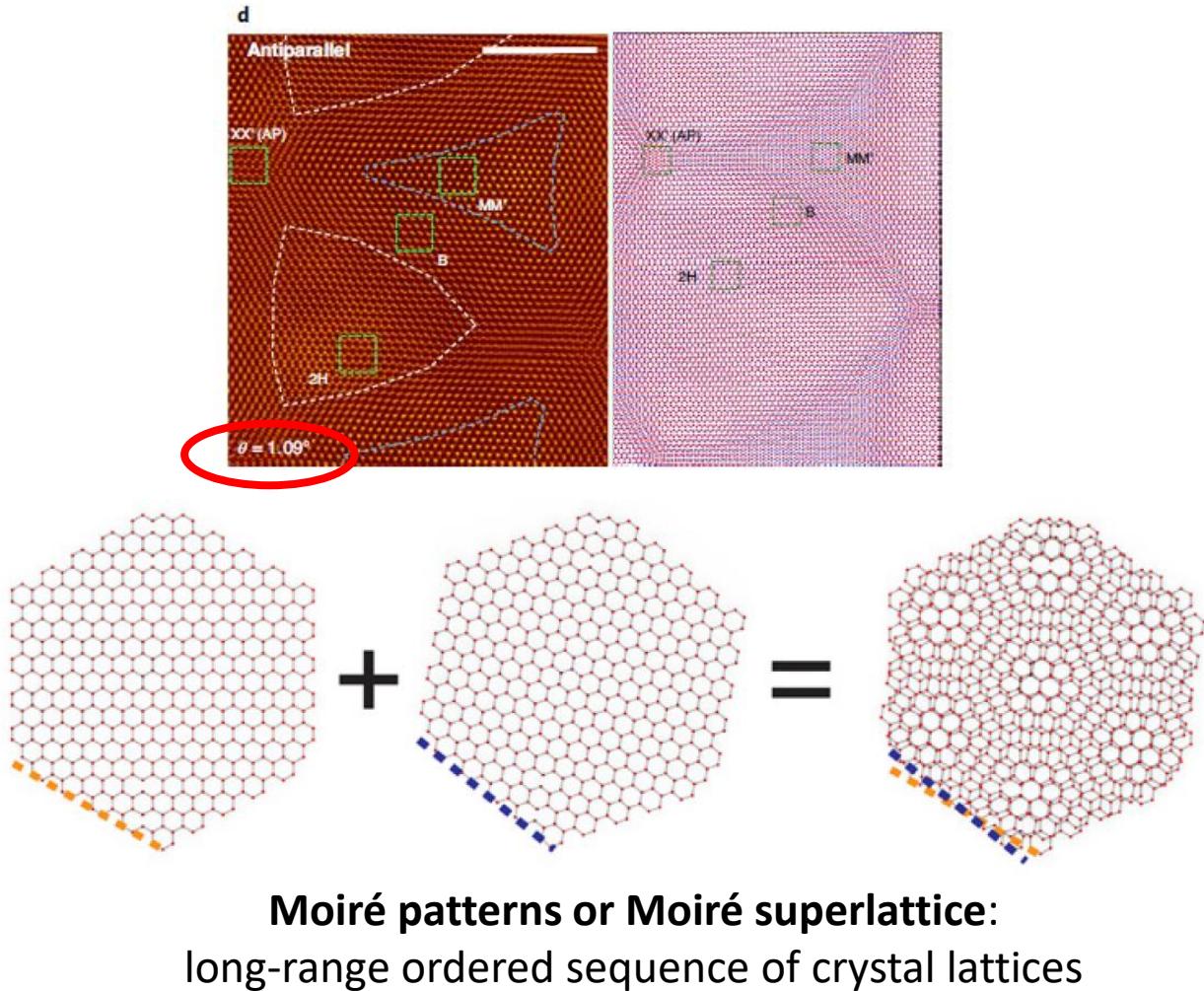


The polarization of the SH emission from a bilayer is a combination of the monolayer emission and the twisting angle



Credit to Prof. Bosco Yu, University of Victoria

Small Twisted Angle: Moiré Patterns



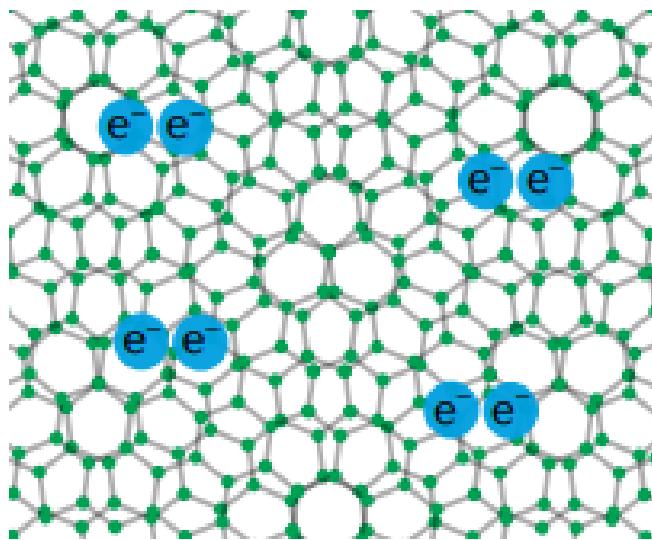
For $\theta < 3^\circ$ (small twist angle):

$$L = \frac{a}{2 \sin\left(\frac{\theta}{2}\right)}$$

Superperiodicity
constant

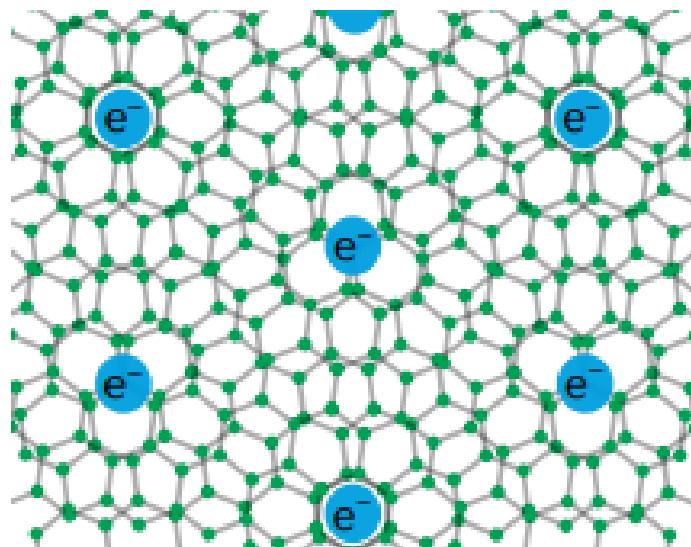
Properties of Moiré patterns

Superconductivity



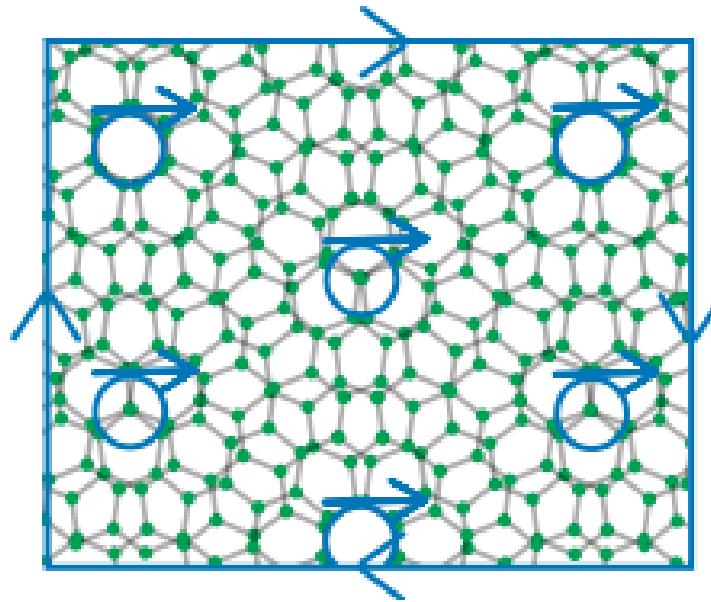
Transition temperature
dependent on θ .

Mott insulator states



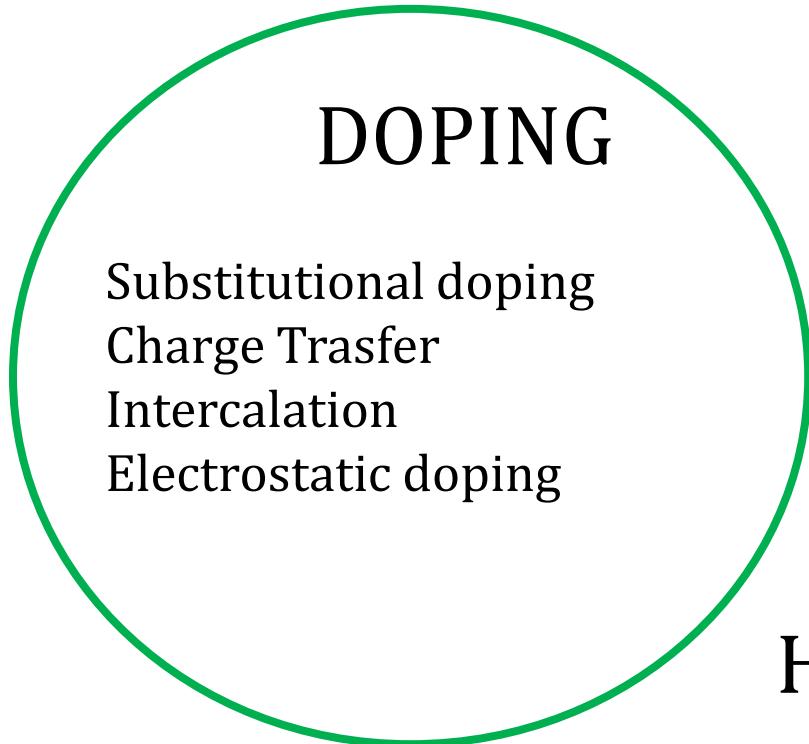
Highly localized states (whose
density depends on θ).

Orbital magnetism



Moiré structuring of local
magnetic moments

How to tune the 2D properties?



PASSIVATION

- Defect passivation
- Surface encapsulation

HETEROSTRUCTURING

- Defect passivation
- Surface encapsulation

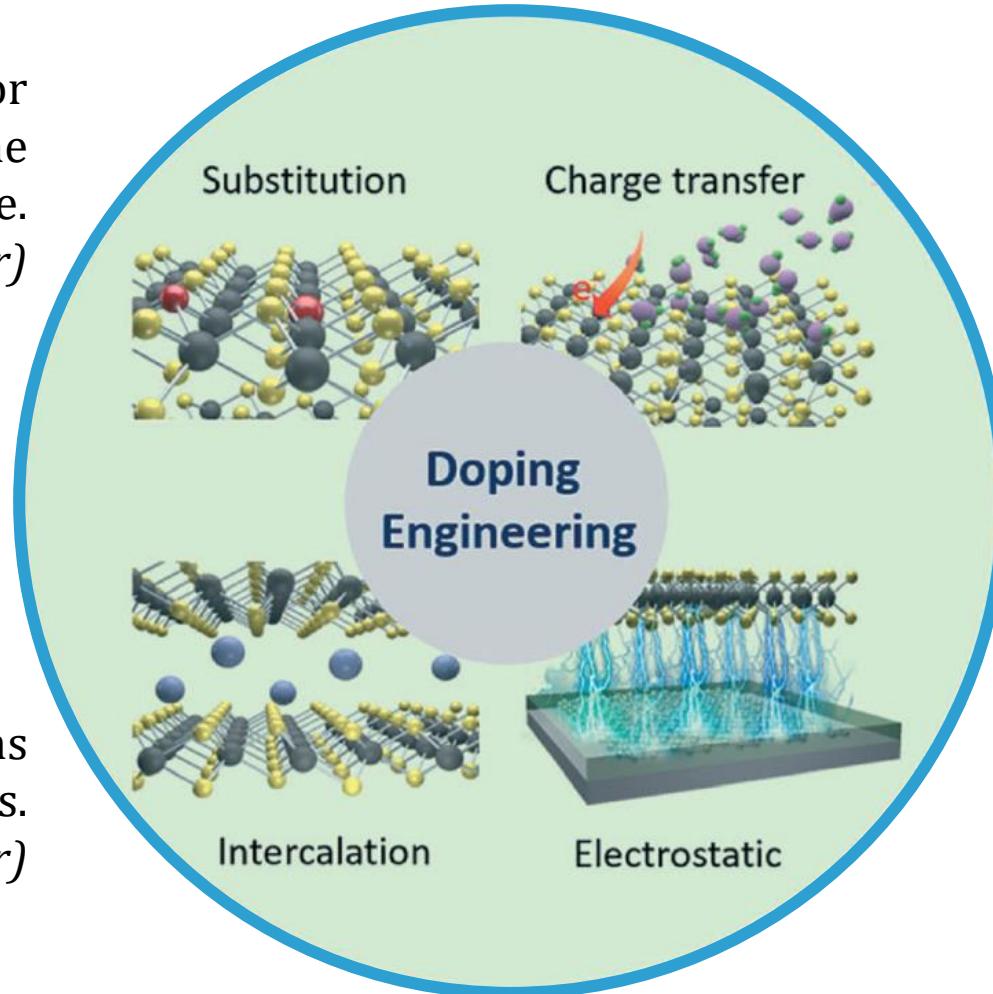
Doping Strategies

Substitution of metal or chalcogen atoms in the lattice.
(*Monolayer/Multilayer*)

Charge transfer from atoms/molecules adsorbed on the surface to the layer.
(*Monolayer*)

Intercalation of atoms between crystal layers.
(*Multilayer*)

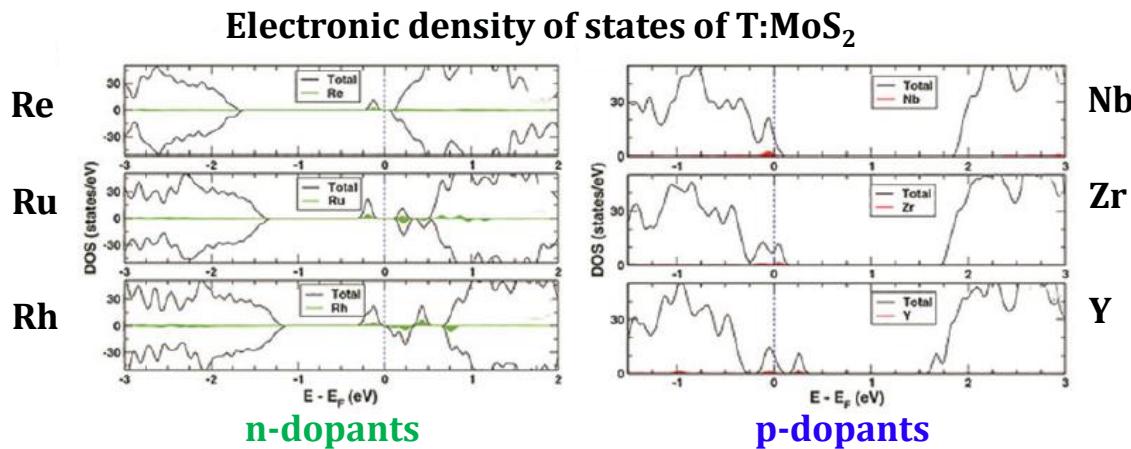
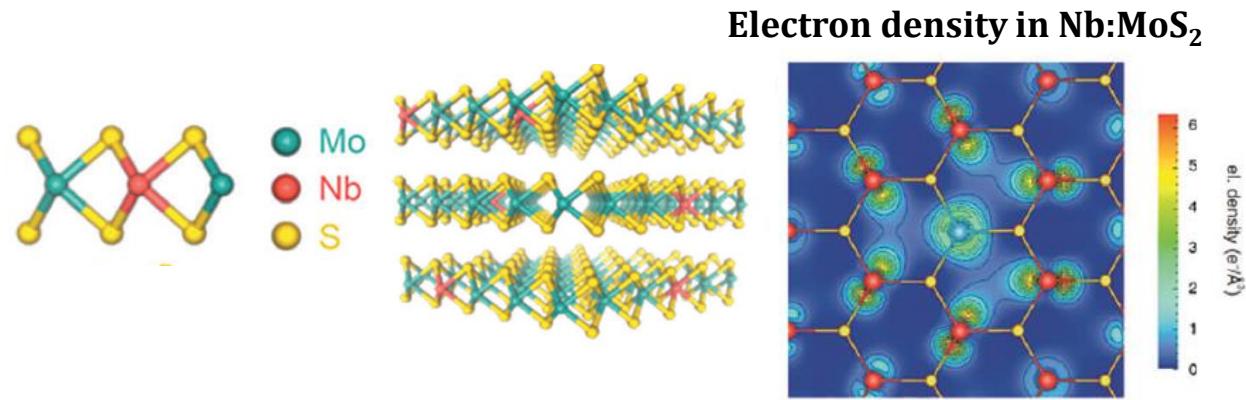
Electrostatic charge pumping.*
(*Mono-, Bi-Layer*)



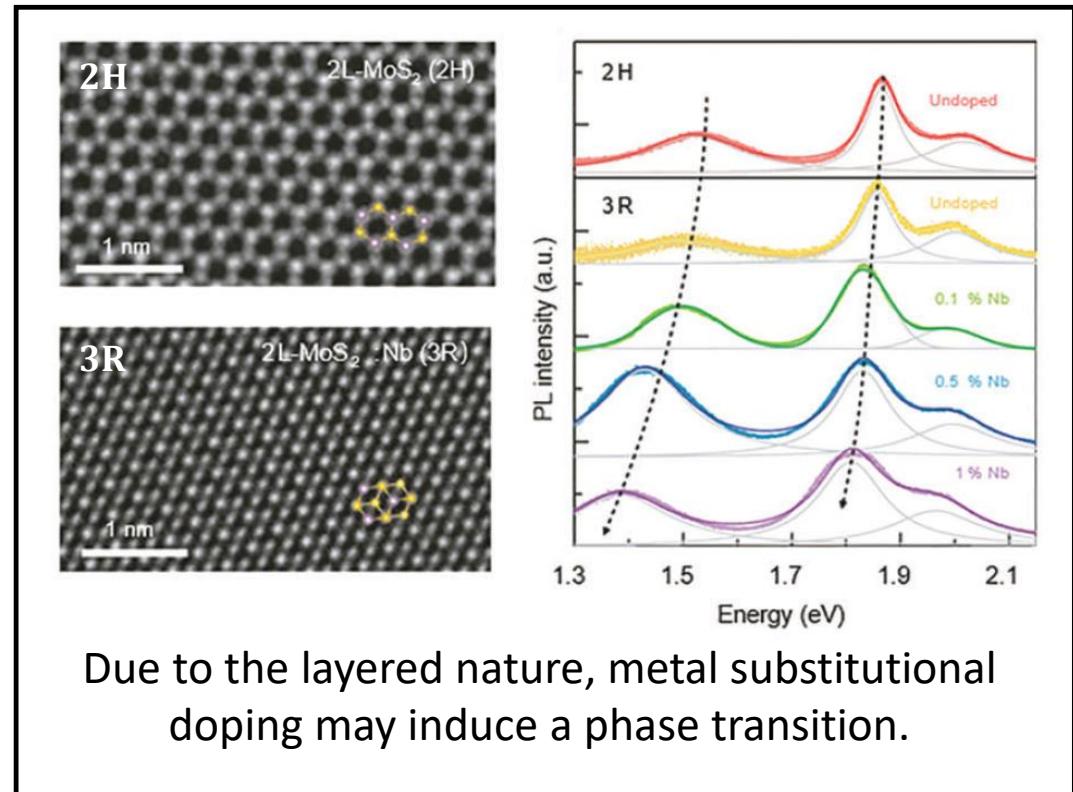
* Following the Grundmann definition (Doping is ... “The modification of the conductivity of a semiconductor using point defects”), this is not doping. This phenomenon occurs also in bulk and thin films semiconductors but its effect can be persistent in VdW materials.

Substitutional Doping (1)

Substitution of metal atoms in the lattice (Mo, W \rightarrow T)



Luo et al., *Nanoscale Horiz.*, 4, (2019)

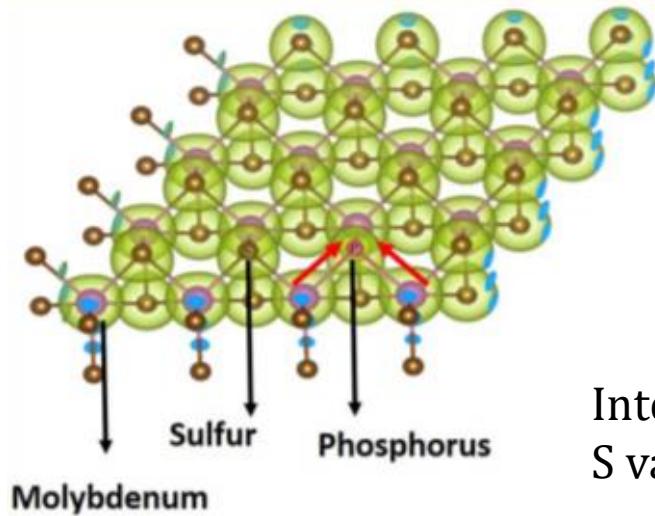


Due to the layered nature, metal substitutional doping may induce a phase transition.

21	Scandio	44,956	22	Ti	47,867	23	V	50,942	24	Cr	51,996	25	Mn	54,938	26	Fe	55,645	27	Co	58,933	28	Ni	58,693	29	Cu	63,546	30	Zn	65,38	31	Gal	69,1
89	Y	88,906	40	Zr	91,224	41	Nb	92,906	42	Mo	95,95	43	Tc	98	44	Ru	101,07	45	Rh	102,91	46	Pd	106,42	47	Ag	107,87	48	Cd	112,41	49	In	114
57-71			72	Hf	178,49	73	Ta	180,95	74	W	183,84	75	Re	186,21	76	Os	190,23	77	Ir	192,22	78	Pt	195,08	79	Au	196,97	80	Hg	200,59	81	Tl	204
104	Ds	105	Ds	106	Ds	107	Ds	108	Ds	109	Ds	110	Ds	111	Ds	112	Ds	113	Ds	114	Ds	115	Ds	116	Ds	117	Ds	118	Ds	119	Ds	120

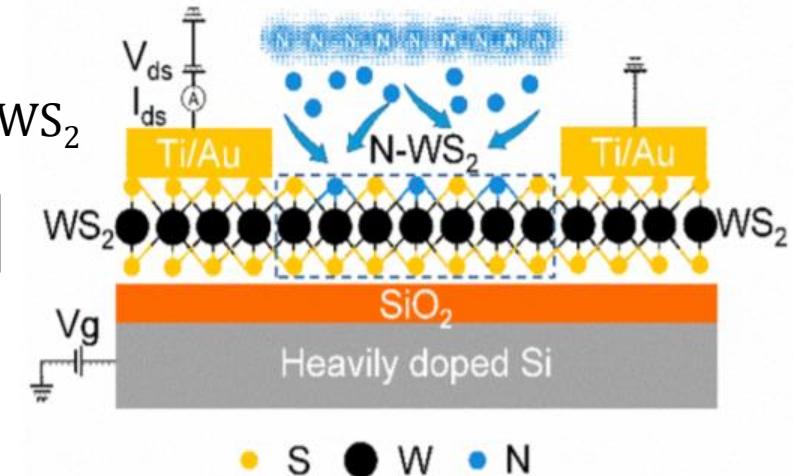
Substitutional Doping (2)

Ion implantation of P and N



p-dopants

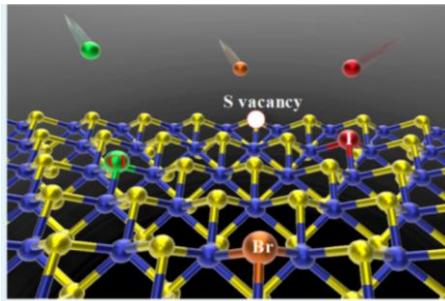
Interstitial P in MoS_2
S vacancy enhancement



Halide assisted Growth

n-dopants

Cl, Br, I in S vacancy sites
Passivation effect



Nipane et al., ACS Nano, 10, (2016)

Tang et al. ACS Nano, 12, (2018)

Wang et al., ACS Appl. Mater. Interfaces, 12, (2020)

Substitutional doping resuming table

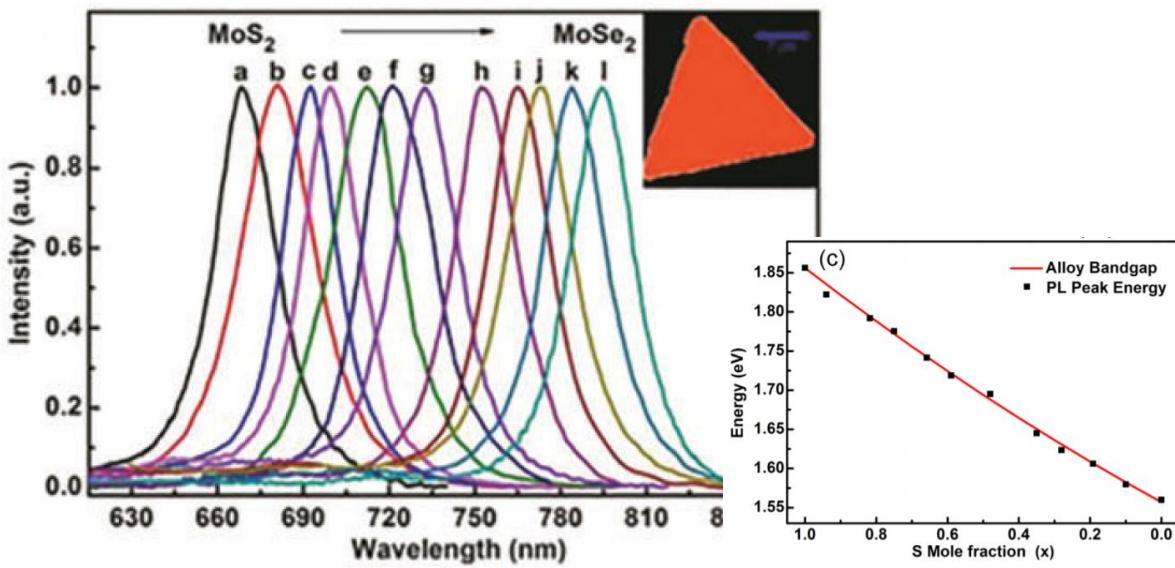
MX_n	Dopant	Type	Concentration [cm^{-2}]	Mobility [$\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$]	Ref.
MoS_2	Nb	p	1.8×10^{14}	14	32
	P	p	$10^{10}-10^{12}$	137.7	33
	Re	n	5.5×10^{12}	—	80
MoSe_2	W	p	4.0×10^{11}	1.6	86
	Cl	n	6.0×10^{11}	60	88
WS_2	N	p	3.83×10^{11}	1.7	87
	S	n	—	68.2	89

2D Alloys

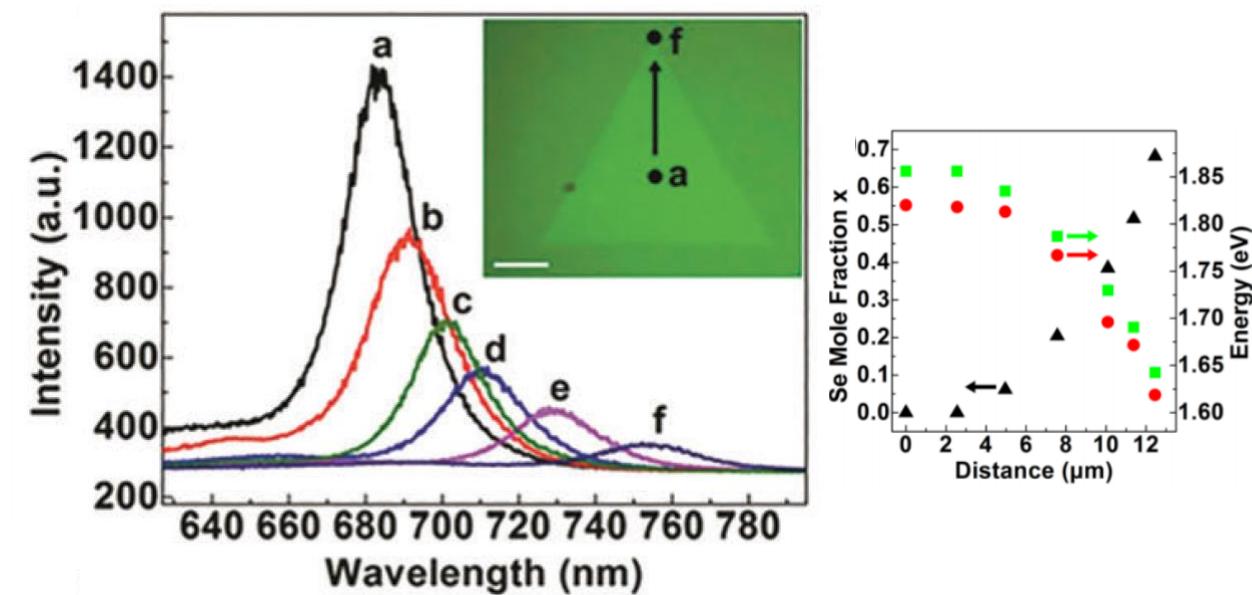
Alloying ~ Isoelectronic doping

Metal and chalcogen alloying induces a modification of the conduction or valence band, directly impacting the band gap and the functional properties.

PL spectra of homogeneous $\text{MoS}_{2x}\text{Se}_{2(1-x)}$



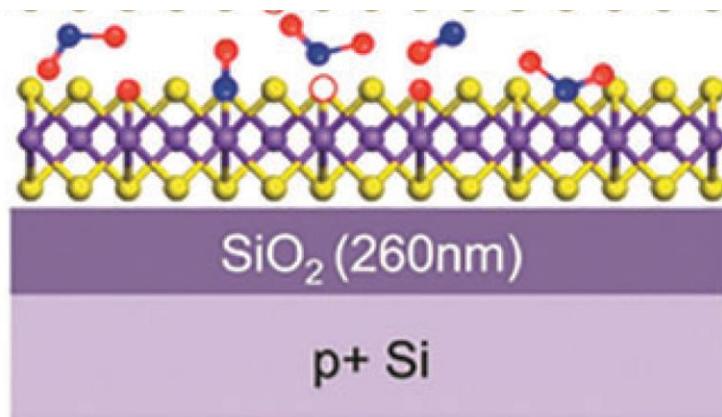
PL spectra of gradient $\text{MoS}_{2x}\text{Se}_{2(1-x)}$



Charge Transfer Doping (1)

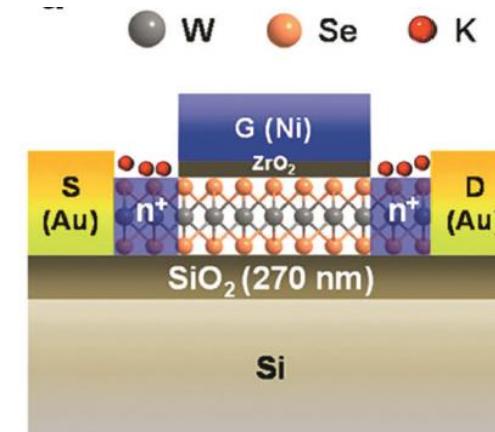
Doping occurs through charge transfer from/to species with different chemical nature which are not chemically bonded with the atomic layer

Gaseous molecules can adsorb on the surface and induce charge transfer (adatom dopants).



TBN: Adsorption occurs on preferential sites such as grain boundaries or vacancies.

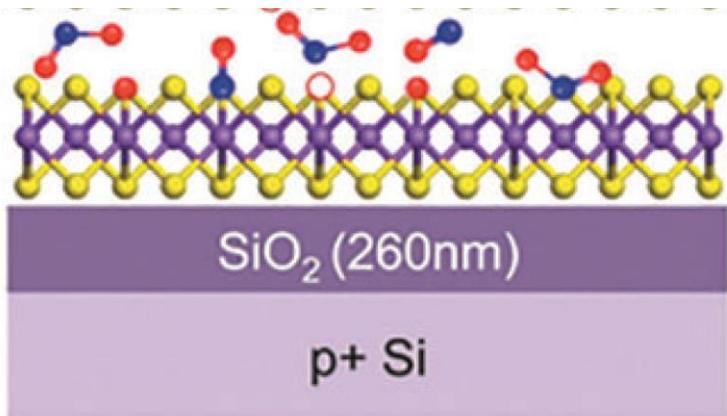
Metal atoms provide electrons/holes to the layer depending on the relative work functions.



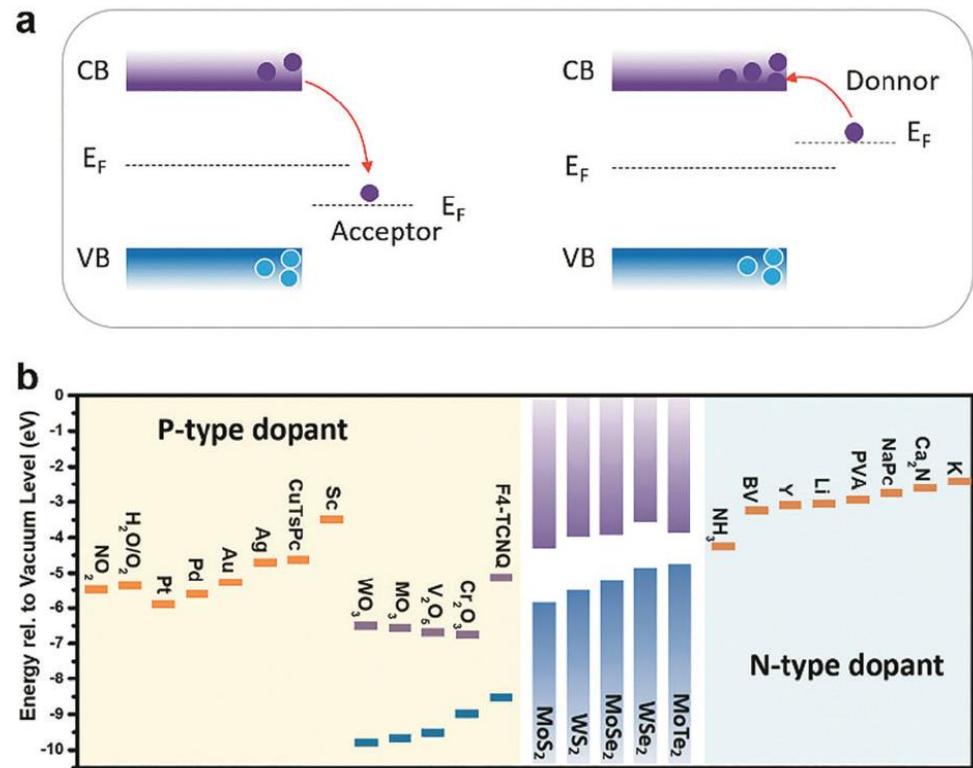
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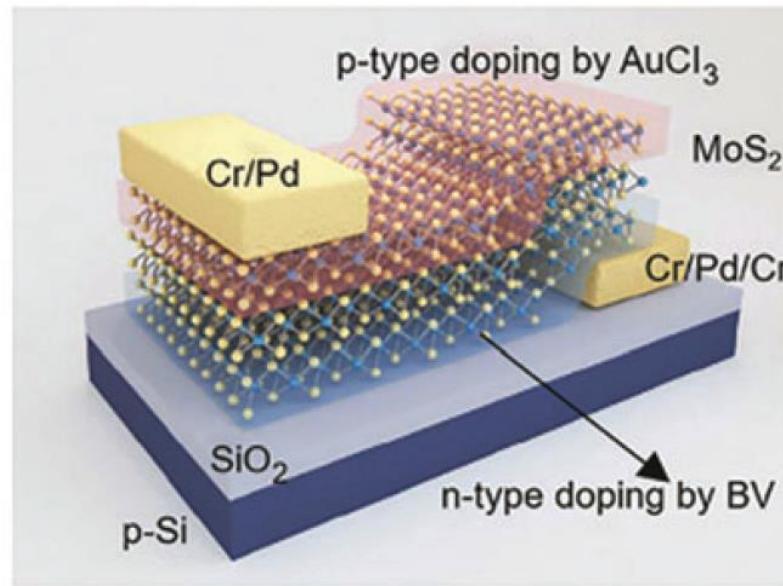


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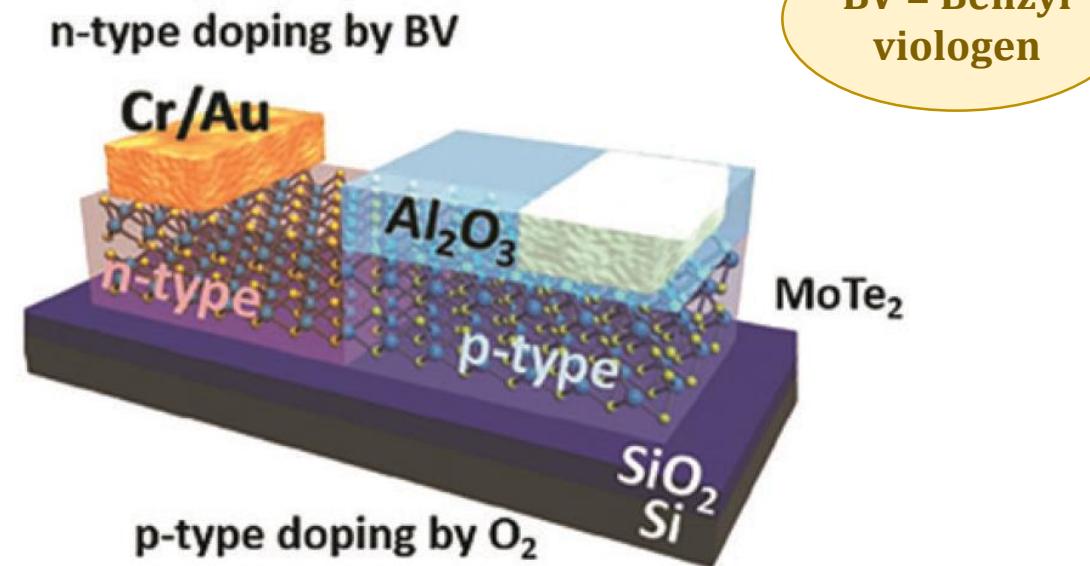


Charge Transfer Doping (2)

Vertical p-n junction



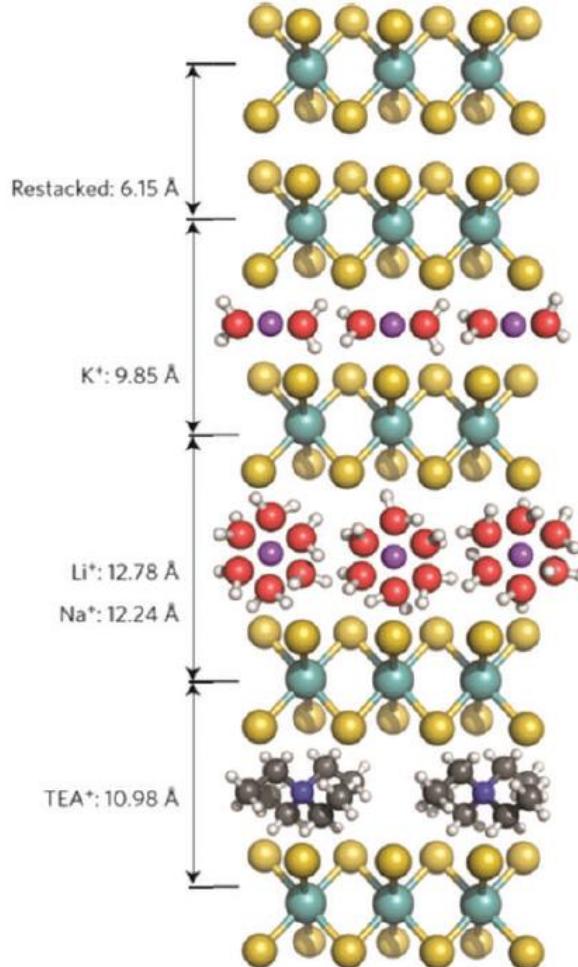
Lateral (Horizontal) p-n junction



Charge transfer allows to dope the material after the synthesis (less impact on the atom arrangement) and it is convenient to engineer selected areas of interest.

Intercalation Doping

Example of intercalation doping in MoS_2

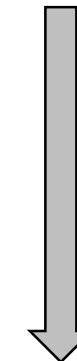


Intercalation is able to modulate the crystal lattice and electronic structure of host materials, as well as providing charges (depending on the donor/acceptor nature of the foreign atoms).

The larger the size of the foreign impurity, the larger the distortion of the crystal and thus the effect on the electronic structure.

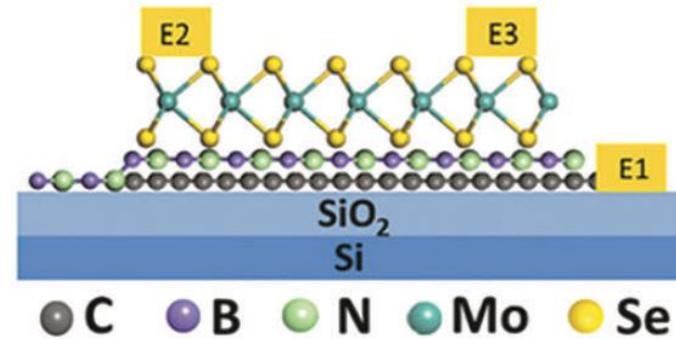
Typical intercalation doping is obtain through:

- *Hydrogen*
- *Alkali Metals (Li, Na, K)*
- *Heavy Metals (Cu, Co)*
- *Organic compounds (Triethylamine)*



Increasing
atomic/molecular
size

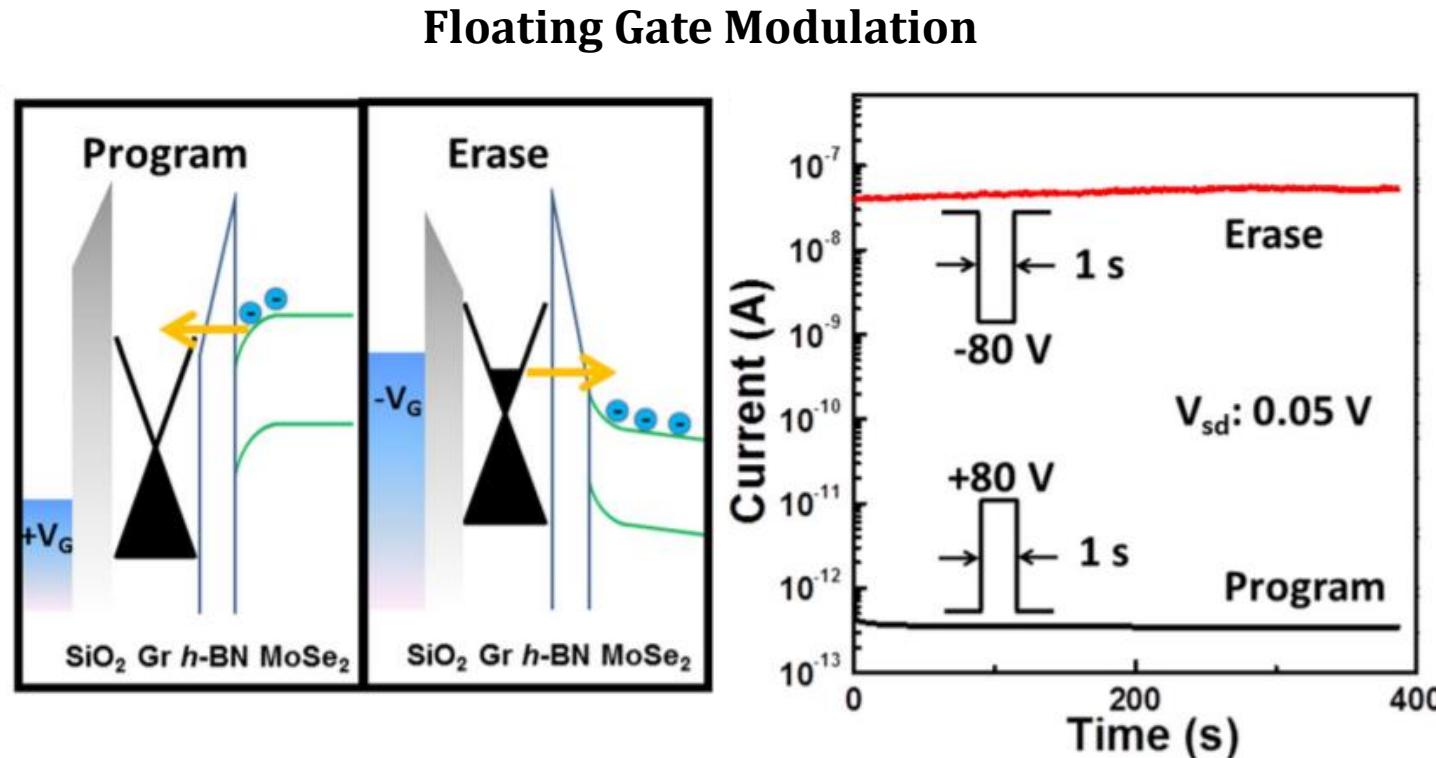
Electrostatic Doping



Gate-controlled potential difference can induce carrier injection into semiconductors.

Usually this phenomenon is NOT considered doping!

Due to their atomic thickness, TMDs are highly sensitive to electric field and thus some method can ensure a doping-like effect even after withdrawal of the gate bias.



Electrons tunnel in from the graphene contact through the h-BN (the direction depends on the applied gate bias, here named «Erase» and «Program»). By applying a high V_g for a short time (1s), the channel conductivity changes for a long time.